

COMPUTER SIMULATION OF  
COPPER AND TUNGSTEN CRYSTAL DYNAMICS  
WITH VACANCIES AND INTERSTITIALS

Gary Lee Vine



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REPORT

United States  
Naval Postgraduate School



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COMPUTER SIMULATION OF COPPER AND TUNGSTEN CRYSTAL  
DYNAMICS WITH VACANCIES AND INTERSTITIALS

by

Gary Lee Vine

Thesis Advisor:

Don E. Harrison, Jr.

June 1971

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REPORT

Computer Simulation of Copper and Tungsten Crystal  
Dynamics With Vacancies and Interstitials

by

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## ABSTRACT

The effects of point defect implantation in copper and tungsten crystal lattice have been studied by computer simulation techniques. Vacancies, interstitials, and replacement impurities have been created in the first five layers of the free (100) surface of these crystals. The subsequent binding energies of these defects in tungsten were compared with experimental temperature dependent desorption peaks, corresponding to binding energies of neon defects in a tungsten crystal. Interstitial and replacement impurity positions in the first three to five layers were found that seem to correspond to the experimental data. Significant results were also obtained which were associated with general surface effects, especially crowdion migration.





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## I. INTRODUCTION

Extensive research has taken place in the last decade in the area of computer simulation of radiation damage in crystal lattices. Two major areas of simulation have been defined. "Dynamic simulation" suggests the firing of an atom or ion against a crystal and the observation of the resulting many-body collisions. Examples include sputtering simulation [1,2,3], in which atoms are ejected from the surface of an ion-bombarded crystal; and channeling simulation [4], in which ions are fired down open channels in non-close-packed structures such as body-centered cubic and diamond lattices. "Static simulation", on the other hand, is concerned with equilibrium positions and energies for point defects in crystals [5,6,7]. This latter area was the concern of this research. Specifically, this simulation attempted to correlate equilibrium potential energies of point defects with experimentally determined binding energies of point defects in Tungsten [8,9].

### A. HISTORICAL BACKGROUND

#### 1. The Problem

Historically, all crystal dynamics computer simulation has been based on the assumption that the complicated many-body problem can be reduced to many two-body problems. This assumption has repeatedly been shown to be a valid one when employed incrementally. Incremental calculations are necessary since a complete solution in closed form is impossible. Small time increments  $\Delta t$  approximated the true time differential  $dt$  of the impossible closed form



solution. Specifically, the desired type, size, and orientation of crystal lattice is stored in the computer, appropriate inter-atomic potentials are chosen, and all mutual forces between atoms are calculated, based on the analytic potential functions. Point defects are introduced, and each atom is then allowed to move incrementally, based on these forces and Newtonian Mechanics [5]. Through proper choice of time increment duration, damping of forces and velocities in each time increment, and sufficient repetition of the procedure, realistic results are obtained.

## 2. The Pioneers and Their Contributions

Pioneering work in this field began in the early 1960's at the Brookhaven National Laboratory. Gibson, Goland, Milgram and Vineyard (GGMV) [5] published the results of extensive work in both static and dynamic simulation. In static simulation they determined equilibrium positions for interstitials and associated potential energies of formation. In dynamic simulation they investigated momentum propagation directions of energetic knock-on atoms (focusing), collision chains, and related topics. They used a central-difference method to obtain velocities and positions from calculated forces. All work was done with copper, and results were correlated with experimental data. Johnson and Brown (JB) [6] did extensive work in static simulation, again with copper. They established that only one stable position exists for a single face-centered cubic (FCC) self-interstitial: the  $\langle 100 \rangle$  split interstitial. Johnson [10] later published further work in this area, with formation and activation energies for various point defects. Enginsoy, Vineyard, and Englert (EVE) [7] and Johnson [11]



repeated most of the earlier calculations in GGMV and Johnson for the body-centered cubic (BCC) case, based on  $\alpha$  iron. They, too, established the existence of only one stable interstitial position, a  $\langle 110 \rangle$  split interstitial.

Girifalco and Weizer (GF) [12] calculated Morse Potential

$$\phi_{ij} = D[\exp\{-2\alpha(r_{ij}-r_o)\} - 2 \exp\{-\alpha(r_{ij}-r_o)\}]$$

parameters for various metals, based on experimental values for the energy of vaporization, the lattice constant, and compressibility. Resulting elastic constants and equations of state agreed satisfactorily with experiment. Girifalco and Weizer [13] later published results of using these Morse parameters in simulating vacancy relaxation dynamics. Anderman [14] used GW's technique of calculating Morse parameters, but instead of summing over an entire crystal, (GW calculated out to the 150th nearest neighbor) Anderman found parameters as a result of summing out to second, third, and fourth nearest neighbors, for use in short-range approximations.

Harrison [1,2,3] has investigated sputtering phenomenon and other surface effects with a modified Brookhaven model, the most significant change being the use of an average force method [15] instead of the central difference method in integrating the equations of motion. (See Appendix C.) He has also calculated repulsive potentials of the Born-Mayer type ( $V_{ij} = \exp(A+Br_{ij})$ ) for many combinations of atoms and ions based on secondary electron emission, and Hartree-Fock atomic electron distributions [16].



### 3. The Potential Function Problem

The most difficult problem encountered by computer simulation has been the proper choice of the potential function. No simple analytic expression, based on either theory or experimental data, has ever been found that completely describes crystal dynamics [17], although many analytic expressions are partially correct. The problem has been three-fold: First, present analytic expressions have narrow regions of validity, i.e., some correctly describe atomic behavior at equilibrium distances, but fail at shorter or greater distances. Second, some analytic expressions are limited because they only apply to interactions between identical atoms. Third, the assumed functions have spherical symmetry, and are technically limited to interactions between closed shell atoms or ions [18]. Although our assumption of a spherically symmetric potential in crystals is only approximately correct, it is nevertheless a very good approximation for FCC structures, and a reasonably good approximation for BCC structures. It is grossly in error when applied to diamond structures.

The atomic potential, with the familiar potential well, sharply repulsive wall and gently attractive tail, varies greatly between different pairs of atoms. Since theory can give only approximate parameters for this complete potential function, experimental data have been used extensively in the formulation of potentials. Other avenues have been opened by computer simulation. Since potential well depths are typically on the order of a few eV, the characteristics of the well can be ignored in high energy dynamic simulation. Low energy dynamic simulation, and even static





simulation, have also been based upon this approximation with useful results. Historically this is how crystal simulation began. GGMV [5] employed a purely repulsive potential of the Born-Mayer (BM) type and applied external forces on all crystal boundaries to hold the crystal together. JB [6] used basically the same technique. For improved equilibrium studies a potential with a well was necessary so GW [12,13] used a Morse potential in their simulation. The Morse function, however, fails at strongly repulsive distances. To satisfy the need for a more versatile potential, capable of handling both high energy and near-equilibrium dynamics, composite potentials were developed, which resemble BM or Bohr

$$(V_{ij} = \frac{r'}{r_{ij}} \exp(A+Br_{ij}))$$

functions at short separations, and Morse functions at equilibrium and greater separations. Specifically, EVE [7] combined a screened Coulomb or Bohr potential, a BM potential, and a Morse potential, in the higher repulsive, lower repulsive, and attractive regions, respectively, of the atomic potential.

Johnson [10,11] in his later papers, used three cubic equations to approximate the true potential. Anderman [14] and Harrison [1,2, 3,4] have used the BM repulsive term together with a Morse well and attractive tail, smoothly fit together by a cubic equation in the region near their intersection.

#### 4. The Point Defect Problem

All early simulation was done with homogeneous systems: All atoms were exactly the same, limiting high energy dynamic simulation to bombardment by atoms identical to the lattice atoms,



and static simulation to consideration of only the vacancy and self-interstitial cases. This limitation was forced by the potential functions, because parameters for the Morse function were based on experimental data for homogeneous media [12]. The methods used could not yield parameters for different-atom pairs. BM parameters, however, are obtainable for different-atom pairs, by methods such as the Hartree-Fock method [16] mentioned previously.

In spite of these limitations, dynamic computer simulation of bombardment by foreign atoms, or static simulation of foreign interstitials, can be done by two alternate methods. First, Harrison [4] has neglected the attractive interactions and has done foreign particle dynamics using repulsion only. Alternately, Johnson [11] has derived a cubic equation for a complete potential with a potential well, based on limited experimental data on carbon defects in iron. However, experimental substantiation for a foreign-particle potential well is much more difficult than for an identical atom potential well.

## B. THE EXPERIMENT

The experimental data which this simulation proposed to explain, were published by Kornelsen and Sinka (KS) [8]. They have bombarded a clean (100) tungsten surface with  $\text{Ne}^+$ ,  $\text{Ar}^+$ ,  $\text{Kr}^+$ , and  $\text{Xe}^+$ , in the energy range of 40 eV to 5 keV. The subsequent "damaged" crystal was heated at a constant rate, and gas desorption rates were measured. Instead of a constant desorption of ions, various distinct peaks were found, categorized into two basic types: a



single large peak at  $1800^{\circ}\text{K}$ , the same for all four ions; and four or five smaller peaks in the  $400^{\circ}\text{K}$  to  $1650^{\circ}\text{K}$  range, which were not in the same position for all four ions. These latter peaks were postulated to correspond to binding energies of various point defects in the first few layers of the tungsten crystal. (See Figure 4.)

This simulation used Harrison's assumption of a repulsive potential only, for interactions between a foreign point defect and other atoms in the lattice. When investigating neon defects in tungsten, all tungsten lattice interactions were based on composite Morse and repulsive Born-Meyer potentials, and all neon-tungsten (Ne-W) interactions were based on a purely repulsive BM potential.



## II. OBJECTIVE

The long-range objective of this simulation was to correlate simulated and experimental binding energies of neon point defects in tungsten. Since the assumption that all Ne-W interactions are purely repulsive was not realistic, the degree to which subsequent simulation results are valid must be based on a known standard. If the simulated binding energies are not correct, a valid correction factor can be applied, if derivable from the known standard. One standard which proved to yield this information was the tungsten-tungsten (W-W) interaction. A tungsten point defect could be treated as an atom of the lattice, and given an interatomic potential identical to all other lattice atoms, the composite Morse and BM potential. This was Method 1. A tungsten defect could also be treated as foreign, and allowed to interact with other lattice atoms with a repulsive potential only (Method 2). If a specific tungsten point defect is treated by both of these methods, an empirical relationship between the repulsive potential assumption and the "true" potential for W-W interactions is obtained.

The objectives of this research were fourfold:

1. Demonstrate that the two methods of treating tungsten point defect in a tungsten lattice yield basically the same physical results, and agree with published results [7,11] concerning split interstitial positions.
2. Develop a general empirical relationship between the binding energies derived by the two methods.





3. Obtain values for binding energies of neon defects in all possible positions in a tungsten surface. Transform these values to more realistic ones using the empirical relationship derived in 2.
4. Compare these results with KS's experimental data.



### III. THE MODEL

#### A. THE CRYSTAL

The model used in this research is the Gay-Harrison [19] model, with modifications by Levy [20], Johnson [21], Effron [22], and Moore [23]. Abbreviations in brackets refer to computer program names for the variable in question.

Both copper and tungsten crystals were simulated. Copper was simulated only to provide an interface between this research and published simulation results. Copper forms a face-centered cubic crystal with an experimentally determined lattice constant, (LC) or cube edge distance of  $3.615\text{\AA}$ . The lattice unit (LU), defined as  $\frac{1}{2}\text{LC}$ , is  $1.8075\text{\AA}$ ; and the nearest neighbor distance, as in all FCC structures, is  $\sqrt{2}\text{LU}$ . Tungsten forms a body-centered cubic crystal, with a LC of  $3.16\text{\AA}$ , a LU of  $1.58\text{\AA}$ , and a nearest neighbor distance, peculiar to all BCC structures, of  $\sqrt{3}\text{LU}$ . All distances in the program are measured in LU. The program could construct (100), (110), and (111) orientations of face-centered and body-centered cubic structures. The copper crystal size was  $8 \times 8 \times 8$ , and contained 256 atoms for the (100) orientation.

The major portion of the simulation was done on the (100) orientation of tungsten, corresponding to KS's experimental work. This tungsten crystal size for Neon point defects was  $10 \times 10 \times 10$ , and contained 250 atoms. Some W-W simulation was done on a  $14 \times 14 \times 14$  crystal; the reasons are explained in RESULTS. The bottom two layers of the lattice were not allowed to move, although they had potential energy, and exerted force on all atoms



in the crystal. The other eight layers were completely free to move, and were included in the dynamic calculations of each time-step.

The surface layer ( $Y = 0$ ) and the second layer ( $Y = 1$ ) were moved forward, simulating actual surface relaxation in the crystal. This relaxation was calculated by Moore [24] using simulation techniques, and tested against previous results by Burton and Jura [25]. Definitions and use of mobile layers, relaxation, etc., were analagous in the copper model, as were all other aspects of the model to be described in this chapter.

## B. THE POTENTIALS

### 1. The W-W Composite Potential

The attractive potential used was the Morse potential, with tungsten parameters calculated by GW [12]. The interaction energy  $\phi_{ij}$ , of a pair of particles  $i$  and  $j$  is:

$$\phi_{ij} = D[\exp\{-2\alpha(r_{ij}-r_o)\} - 2 \exp\{-\alpha(r_{ij}-r_o)\}] \quad (1)$$

where  $D$  [DCON] is the dissociation energy of the pair,  $r_o$  [RE] is the equilibrium separation,  $r_{ij}$  [DIST] is the actual separation, and  $\alpha$  [ALPHA] is a constant.

The repulsive potential is of the BM type, with Harrison's Hartree-Fock parameters. The interaction energy  $V_{ij}$ , is

$$V_{ij} = \exp(A+Br_{ij}) \quad (2)$$

where  $B$  [EXB] is always negative,  $A$  [EXA] is always positive, and  $r_{ij}$  [DIST] is the actual separation. The constants [EXA] and [EXB] are peculiar to the W-W interaction.



The ranges of the W-W composite potentials were as follows: the BM repulsive potential operated from 0 to  $1.5\text{\AA}$ ; and the Morse potential from  $2\text{\AA}$  [ROEB] to  $5.38\text{\AA}$  [ROEC]. In LU, the dimension in which all calculations were done, these constants were .9494, 1.2658, and 3.4000 LU. [ROEC] was chosen to include interactions out to the fourth nearest neighbor (NN4) at  $\sqrt{11}$  LU = 3.317 LU but not NN5 interactions, at  $\sqrt{12}$  LU = 3.464 LU. Note, however, that slight displacements of NN5's might allow their inclusion in potential and force calculations. The gap between  $1.5\text{\AA}$  and  $2\text{\AA}$  was filled with a cubic function, which matched to the other potentials and slopes at [ROEA] and [ROEB].

## 2. Purely Repulsive Potentials

For foreign point defect interactions, i.e., Ne-W, or W-W Method 2, a repulsive potential only was used. The potential was again a BM, with the constants labeled [PEXA] and [PEXB]. For the W-W, Method 2 interaction, [PEXA] = [EXA] and [PEXB] = [EXB]. Ranges for foreign point defect interactions, however, were different, and the potential itself was modified at the cutoff point. Whereas the BM part of the composite potential extended out to about .95 LU, the modified BM potential used for foreign defects was allowed to extend to  $\sqrt{3}$  LU, corresponding to the NN1 distance [ROE]. Cutting the potential off at [ROE] left a step of about .05 eV for Ne-W (.2 eV for W-W) at the NN1 equilibrium position. Since neither discontinuities nor repulsive potentials were desired at this equilibrium position, we "eroded" [15] the potential by subtracting  $V([\text{ROE}])$ , or about .05 eV from  $V(r_{ij})$  for  $r_{ij} < [\text{ROE}]$ . Calculated forces, based on these eroded potentials must be modified also, but for a different reason. It is possible





to conceive of a case where an atom is further away from the defect than [ROE] at the beginning of a timestep, but closer than [ROE] at the end. The force has essentially "turned on" in the middle of the timestep. The modification gives such an atom a force which is less than the final force by approximately a factor proportional to the ratio of distance traveled outside [ROE] to the total distance traveled during the timestep [15]. (See Appendix B.)

### C. THE TIMESTEP

Motion caused by these forces must be found by an approximate numerical method of time integration. As in previous work with this model, the average force method [15] was used. In this method, all mutual forces were calculated in subroutine STEP. Based on these forces, new temporary velocities and positions were found. Forces were again calculated, based on the temporary positions. The final positions were then calculated from the average of these two force determinations. All velocities were then either zeroed or halved as a damping method. This constituted one timestep.

For this average force method to work properly, the  $\Delta t$ [DT] which approximates dt in the integration must be kept small. Too small a value for [DT], however, would result in excessive computer time. The choice of [DT] was also complicated by the fact that [DT] must be kept much smaller earlier in the program, when velocities, forces, and energies are large, but can be allowed to grow larger as the simulation approaches equilibrium. For this reason, at the end of each timestep, a new [DT] was calculated



for use in the next timestep. The parameter chosen to control  $[DT]$  was  $[DTI]$ , the distance, measured in LU, which the most energetic atom was allowed to move before starting a new timestep.  $[DTI]$  has varied between .001 and .02, depending on such conditions as original position of the point defect, relative masses of atoms, etc. In general,  $[DTI]$  must be kept very small when high velocities are expected, and can be increased when all motion is expected to be "sluggish". In actual practice  $[DT]$  and  $[DTI]$  are related to both the velocity of each particle and the force on each particle. To insure that no particle traveled more than  $[DTI]$  we ensured that  $[DT]$  was small enough so that neither the velocity of the most energetic atom nor the force on the most stressed atom would result in motion greater than  $[DTI]$ . (See Appendix C.)

#### D. FOREIGN INTERSTITIALS

##### 1. Unequal Mass Implications

Many changes in the program were necessary when a foreign defect was included in the lattice. These changes were especially necessary when the defect was much lighter than the lattice atoms; i.e., neon in a tungsten lattice. First, in the average force calculations, a separate section had to be added for the calculations for the primary, or "bullet", based on the bullet mass  $[BMAS]$ . Second, the potential energy between two unequal mass atoms was split in proportion to their reduced masses (see Appendix D). Third, the section that determined the new timestep duration was originally based on the lattice atom mass. Since the light interstitial is usually the most energetic or most stressed



atom, very erratic behavior was observed until the timestep duration calculations were revised to handle two different masses (see Appendix C). Finally, a significant mass difference between defect and lattice atom required a reduction in [DTI]. For the neon-tungsten simulation, a [DTI] of .5% was used.

## 2. Ionization State and Repulsive Potentials

The major portion of the Ne-W work was done with the assumption that tungsten was in a +6 state, and neon was neutral in the lattice. Experimentally KS fired neon in a +1 state into tungsten, but once implanted, the ionization of neon was unknown. All combinations of  $W^0$ ,  $W^{+1}$  and  $W^{+6}$  with  $Ne^0$  and  $N^{+1}$  were subjected to Hartree-Fock analysis. (See Figure 5.) Only  $Ne^0-W^{+6}$  interacted in an approximately exponential manner and could therefore possess realistic BM parameters. Attempts to linearize  $Ne^0-W^{+1}$  and  $Ne^0-W^0$  were made, and subsequent BM parameters were determined. The results of such changes did not significantly influence the results of this investigation.

## E. RUNNING TIME

The following factors effected the problem running time: range of potential, size of crystal, depth of mobile layers, and degree of damping. First, the range of the potential was picked to include at least NN4 interactions. The range used for the tungsten simulation was 3.4 LU, which includes interactions out to NN4. The error made by neglecting NN5 interactions was only 3% in the binding energy of an interstitial, but the omission of NN5 interactions cut running time almost 10%. Second, the size of crystal and depth of mobile layers were picked as small as possible, for



reduced running time, but were at least large enough to completely contain the potential range. Third, the half velocity method of damping was used whenever possible. In general, when velocities were zeroed at the end of each timestep, a timestep took about ten seconds, and equilibrium was reached in about 300 timesteps. When velocities were halved, each timestep again took about ten seconds, but equilibrium was reached in about 150 timesteps.

It was originally expected that increasing [DTI] would decrease running time. Most W-W simulation was done with [DTI] = 2%; i.e., the most energetic or stressed atom could travel .02 LU before the damping of velocities and the starting of a new timestep. When [DTI] was increased, the atoms moved more erratically toward equilibrium, and vibrated there, but did not achieve equilibrium significantly sooner. (See Figure 6.)

## F. SUMMARY

In summary, the steps of the program are outlined:

1. Variables are initialized, constants established, and input data read in.
2. Scaling factors and time saving multipliers are calculated.
3. Morse and BM potential functions are calculated based on input data. Subsequent forces, based on derivatives of these functions are calculated. Potential erosion and force modifications are performed.
4. Potential cutoff's [ROEA], [ROEB], [ROEC] are established and the smooth fitting cubic equation is placed in the gap.
5. The desired crystal type, size, and orientation is built, and the point defect positioned (see Appendix A).





6. Mutual potential energies of all atoms in the crystal are calculated. Local potential energy is calculated. (See Appendix D.)
7. All initial positions and potential energies are printed, along with total potential and total kinetic energy, local potential energy, and the change in local potential energy.
8. The first timestep is started, with an arbitrary running time of  $10^{-14}$  sec. Velocities and positions are calculated by the average force method, and the maximum velocity [EMAX] and maximum force [FMAX] are found.
9. A new [DT], based on [EMAX], [FMAX], and [DTI] is calculated for use in the next timestep. (See Appendix C.)
10. All velocities are zeroed or halved as an energy damping method, and the process (8. to 10.) is repeated.
11. At selected timesteps, all changes in position ([DX], [DY], [DZ]), velocities ([VX], [VY], [VZ]), and kinetic, potential, and total energies [PKE], [PPE], [PTE] for each atom in the crystal are printed.
12. The program is ended after a pre-selected timestep, with a final printout of position and potential energy of each atom, as in Step 7.



#### IV. RESULTS

KS's experimental data indicated that four or five interstitial positions in the first few layers of a tungsten lattice could be found that would result in different binding energies. It was soon found that many parameters in the program could effect the results, and so a systematic attempt to isolate the effects of each individual parameter was undertaken.

##### A. THE CRYSTAL

As explained in Appendix A, the  $Y = 0$  plane was the crystal surface; the  $Y = 1$  plane was the first layer beneath the surface, etc. Each atom in each layer was then designated by appropriate  $x$  and  $z$  coordinates. This construction was independent of type of lattice; i.e., the surface layer in either BCC (100) or FCC (100) was  $Y = 0$ , etc. An interstitial that escaped the lattice normal to the surface travelled in a  $\langle 010 \rangle$  direction, and an ion that escaped normal to a side travelled in either a  $\langle 100 \rangle$  or  $\langle 001 \rangle$  direction.

The dimensions of the lattice had a great bearing on the results. In general, the larger the crystal, the more realistic the results, but increased computer time prevented the use of a size bigger than absolutely necessary. All point defects were placed as close to the center of each plane as possible, and the  $x$  and  $z$  dimensions of the lattice  $[IX]$  and  $[IZ]$  were chosen to completely enclose a circle of radius  $[ROEC]$  from the point defect. In this way any point defect in the center of the lattice would not feel



the effect of the sides of the lattice, especially unequal numbers of atoms in all directions. In the y direction, the lattice was again built deep enough to completely contain the radius of the potential of a point defect placed at the center of the lattice. To simulate the effect of an infinitely deep lattice, the bottom two layers of the crystal were held immobile, but still allowed to interact with all mobile atoms above them. The tungsten crystal size used most often was a 10 x 10 x 10 cube with the bottom 10 x 2 x 10 volume held rigid.

Often erratic behavior in the simulation could be eliminated by simply increasing the crystal size. This was especially true for the problem of crowdion migration.

## B. CROWDION MIGRATION

Crowdion migration is a chain reaction of single lattice site jumps initiated by interstitial implantation. If the chain reaction ends by pushing the surplus atom into an already existing vacancy, the interstitial-vacancy pair is called a Frenkel pair. A Frenkel pair can also be created dynamically by moving an atom from its lattice site to a nearby interstitial position, from where it can cause migration back to the vacancy. If the migration cannot find a vacancy, and travels all the way to the surface, the surplus atom forms a "stub". Normally, migration is always in a closed packed direction; i.e., in the  $\langle 111 \rangle$  direction in BCC. It was discovered, however, that this rule was modified near a surface, since an imbalance of forces in the direction normal to the surface automatically pushed a crowdion in that normal direction into a stub position. In the tungsten



lattice, for instance, a tungsten interstitial that did not initiate crowdion migration would reach equilibrium in a  $\langle 110 \rangle$  split interstitial position, as previously found by EVE [7]. A tungsten interstitial that did initiate crowdion migration would sometimes migrate in a  $\langle 111 \rangle$  direction because of closed-packedness, or sometimes in a  $\langle 100 \rangle$  direction if implanted near a (100) surface. Crowdion migration was never found in a  $\langle 110 \rangle$  direction, since this is the least closed-packed of these three directions. (Hence the tendency toward split-interstitials in this direction).

Crowdion migration was a very common process near a lattice surface. It was found, however, that varying the choice of atoms, the range of the potential, and the rate of energy damping could enhance or reduce the tendency toward crowdion migration. Also, already mentioned was the fact that increased crystal size re-reduced crowdion migration. Particular attention was paid to the proper choice of values for these parameters, in order to correctly determine whether or not crowdion migration actually existed. This question of crowdion migration was especially critical in this simulation, since the binding energy of a particular atom is a direct function of the nearness of its neighbors. An atom in a split interstitial position feels a more repulsive potential than an interstitial that has initiated crowdion migration and 'stolen' a lattice site and has thus reformed the original perfect lattice with every atom in a normal lattice site.

#### 1. Choice of Atom

Some elements tended to initiate crowdion migration more than others. This applied to both choice of lattice atom, and





choice of interstitial atom. For instance, crowdion migration was much more common in tungsten than in copper. This was due to both the size of the tungsten atom and the nature of the crystal. Also it was found that different element point defects in the same lattice produced varying degrees of crowdion migration. A neon interstitial is so small and light that it never initiated crowdion migration, even when only one layer separated it from the surface. An argon interstitial initiated crowdion migration at the surface, but not deeper in the lattice. A tungsten interstitial always initiated crowdion migration, unless placed at the center of a huge  $14 \times 14 \times 14$  tungsten lattice. This is an example of increasing crystal size to prevent crowdion migration. In general it can be stated: the more massive the interstitial, the more probable crowdion migration.

## 2. Range of Potential

In surface simulation, the range of the potential was a critical factor, since it determined whether or not an atom could "see" the surface. Because copper has been the standard element for lattice simulations, many versions of a copper potential with various ranges, have been determined. As mentioned previously, GW [12] calculated a Morse potential for copper that effectively had an infinite range (150th nearest neighbor). If this potential is truncated at very close ranges, i.e., NN1 or NN2, the potential is seriously underestimated. This under estimate rapidly diminishes as the truncation range increases. Since GW parameters for the Morse potential could not be used for NN2 interactions, Anderman [14] calculated parameters for a Morse copper potential that would approximate GW's results in simulations truncated after



NN2. He did this by deepening and broadening the well. Although Anderman parameters and GW parameters led to very similar results in an infinite lattice, they led to quite different results in this simulation. In general, if the range of a point defect potential function overlapped a surface, crowdion migration would take place toward that surface, because of an imbalance of forces in the normal direction. The effect was a little more complex than this because of surface relaxation: if the range of the point defect potential function overlapped a relaxed surface layer, the slight force imbalance would again result in crowdion migration. According to GGMV, "the machine calculation showed that this atom rapidly moved...in a direction determined by minor asymmetries in the starting conditions..."<sup>1</sup>. In this copper simulation, an interstitial placed in the fourth layer with a GW potential range of 3.1 LU (NN4) caused complete crowdion migration, resulting in a copper stub on the surface. An identical run with Anderman parameters for an NN2 potential to a range of 2.4 LU resulted in a  $\langle 100 \rangle$  split interstitial with minor, damped migration to the surface. Instead of a stub copper atom as before, four copper atoms in the surface layer bulged about .4 LU.

Another example of a short range potential which demonstrated this lack of ability to initiate crowdion migration was the repulsive foreign defect potential, with a range of  $\sqrt{3}$  LU. In copper, this potential quickly led to split interstitial positions and no crowdion migration for all copper interstitials

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<sup>1</sup>Gibson, J.B., Goland, A.N., Milgram, M., and Vineyard, E.H., "Dynamics of Radiation Damage," The Physical Review, V. 120, No. 4, p 1237, Nov 15, 1960.



except those placed in the first two layers. In tungsten, even this short range potential could not retard crowdion migration in the  $10 \times 10 \times 10$  lattice. Only in the center of a  $14 \times 14 \times 14$  was a tungsten split interstitial stable. This stability applied only to the short range repulsive potential: a repeat run using the standard composite potential with a range of 3.4 LU initiated crowdion migration. This increased range enabled the interstitial to find minor asymmetries in even a  $14 \times 14 \times 14$  lattice.

### 3. Energy Damping

Energy damping was accomplished in this simulation by reducing each atom's velocity at the end of each timestep. Two methods were used: at first, each velocity component of every atom in the crystal was zeroed at the end of each timestep. Later, the halving of each velocity component at the end of each timestep was employed to save computer time. In a tungsten lattice the results of both methods were the same; all final positions and binding energies were identical. Neither method prevented crowdion migration. In copper, these two methods led to slightly different results. Although the final position and binding energy of an interstitial was almost identical, and although crowdion migration was initiated in both cases (GW's parameters and a 3.1 LU range were used), the zeroed velocity method had damped the migration significantly by the time it reached the surface, whereas the halved velocity method caused a complete, undamped migration to the surface.



### C. INTERSTITIAL IMPLANTATION

All interstitials were placed in the obvious holes in a hard sphere, close-packed lattice model. (See Figure 7.) Every "hole" in the tungsten lattice had exactly the same geometry; i.e., two neighbors 1 LU away; four neighbors 2 LU away, four neighbors 3 LU away, etc. The only factors which differentiated between these identical holes and thus led to different binding energies were: layer number, or lattice depth, and open channel direction. An interstitial in the third layer was more tightly bound than one in layer two, etc. Also, an atom in a given layer could be placed in two types of holes: one in which the interstitial was in the BCC  $\langle 010 \rangle$  open channel direction, in which case the interstitial could "see" the surface; and one in which the interstitial was in the BCC  $\langle 100 \rangle$  or  $\langle 001 \rangle$  open channel, in which the interstitial could not "see" the surface. Note, however, that if an atom could not "see" the surface, then there was no difference between these two positions, since both have two neighbors 1 LU away, four neighbors 2 LU away, etc. Note also that even if these two sites are identical and possess exactly the same binding energies, the difference might still show up in diffusion probabilities: an interstitial in a  $\langle 010 \rangle$  open channel in the second layer must only move two lattice units to escape the crystal. An interstitial in a  $\langle 100 \rangle$  or  $\langle 001 \rangle$  open channel must move 1 LU in either the x or z direction into an open channel, and then 2 LU to escape; i.e., it must move like a knight in chess. This extra step might lead to a different diffusion probability.





#### D. THE TUNGSTEN LATTICE SELF DEFECT

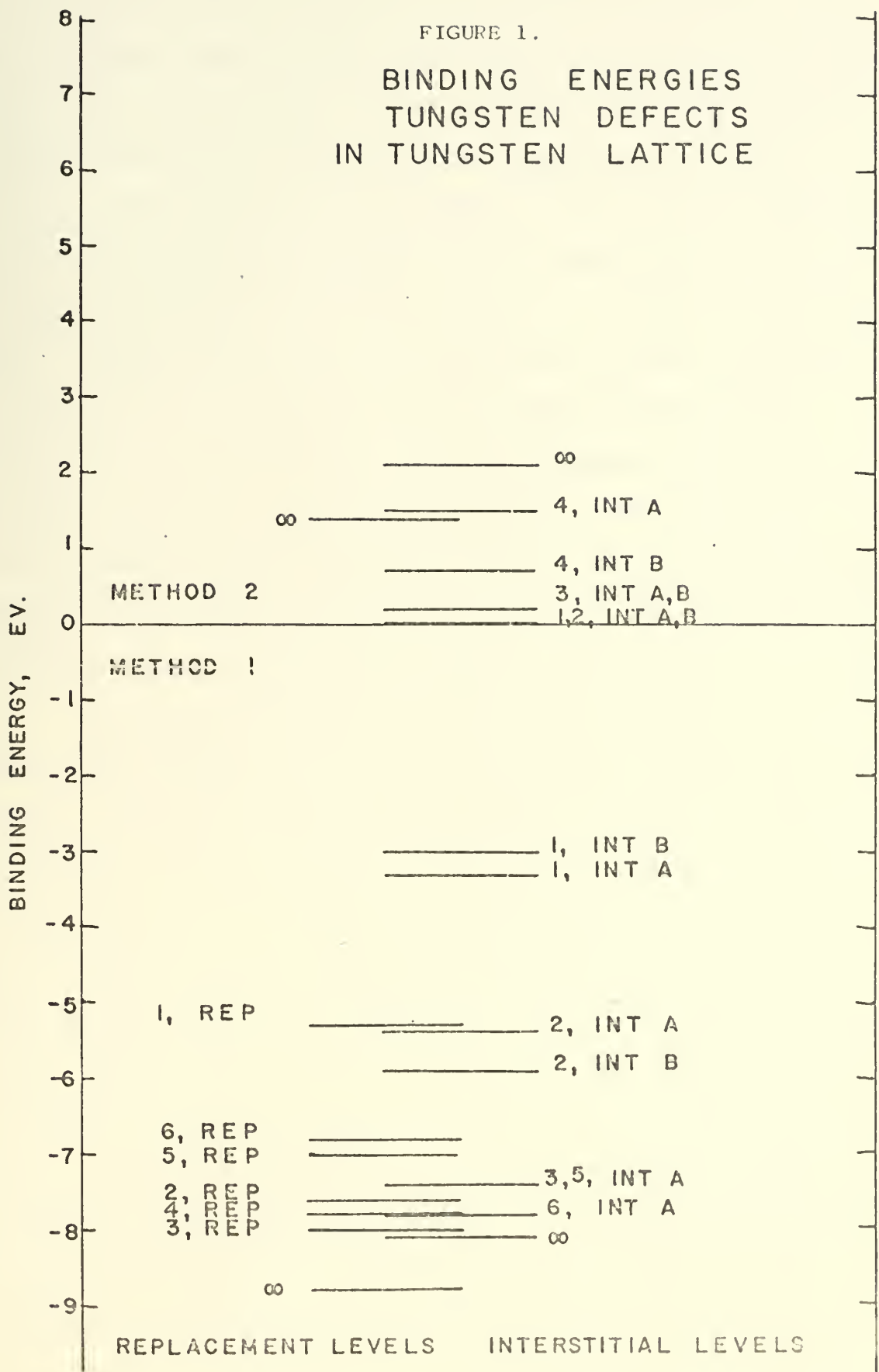
The tungsten self interstitials and self replacement defects were the chosen standard for this analysis, as explained in the in the OBJECTIVE. The tungsten defects could be treated as lattice atoms and allowed to interact with all other atoms with the composite potential (Method 1); or they could be treated as foreign defects and allowed to interact with only a repulsive potential (Method 2). A total of three different defect positions were simulated: an interstitial in a  $\langle 010 \rangle$  open channel (int A), an interstitial in a  $\langle 100 \rangle$  or  $\langle 001 \rangle$  open channel (int B), and a replacement atom (rep) in a lattice site. (See Figure 7.)

##### 1. Interstitials

As previously mentioned, all tungsten interstitials initiated crowdion migration when treated by method 1. An interstitial treated by method 2 also initiated crowdion migration unless buried in the center of an enlarged  $14 \times 14 \times 14$  lattice. Because an interstitial that has pushed its neighbors away has a lower potential than one that has not done so, the numerical values for binding energy of tungsten interstitials could not serve as a true standard for comparison with W-Ne results. Qualitatively, however, much could be learned from the W-W energy levels. First, it was expected that all energy levels of a defect found by Method 1 would be negative at equilibrium. Values for the composite potential can be either negative or positive, but are positive only at very small separations. A negative potential energy means the atom is bound in the crystal. As shown in Figure 1, on the next page, the first two interstitial levels for the W-W reaction, Method 1, were at -3.0 eV and -3.1 eV, corresponding to



FIGURE 1.  
 BINDING ENERGIES  
 TUNGSTEN DEFECTS  
 IN TUNGSTEN LATTICE





the two interstitials in the first layer (int A and int B). The next two levels were at -5.4 eV and -5.9 eV, corresponding to the interstitials in the second layer. Interstitials in the third layer and deeper had binding energies ranging from -7.4 eV to -8.1 eV. The value of -8.1 eV, labeled " $\infty$ " was obtained from the interstitial placed in the center of the seventh layer of a  $14 \times 14 \times 14$  lattice. Since this value, and all other values for Method 1 binding energies were reached after crowdion migration, they were all expected to be lower than they would be without crowdion migration. The only way the true binding energy of a tungsten interstitial could have been found would have been to find a tungsten crystal size large enough to contain the crowdion migration of a tungsten interstitial with the long-range composite potential. Compute running time made this impossible.

Also shown in Figure 1 are the binding energies for the Method 2 W-W interstitials. Note, first, that they were all positive. This was again expected, since the potential equation for Method 2 is positive over all space. Note, second, that the binding energies for interstitials in the first two layers were zero. This was because all purely repulsive atoms in these first layers escaped the lattice completely. The other positive levels shown, were incomplete, because many interstitial positions did not possess stable energy levels. The unstable levels oscillated because of significant lattice motion, caused by crowdion migration, and measured by a short range potential. The range was so short, that significant jumps in binding energy occurred when an atom moved into, or out of the range of the potential. Evidently,



small vibrations in atoms with an equilibrium distance of about  $\sqrt{3}$  LU from the interstitial, frequently caused crossings of this range limit, adding or subtracting energy from the binding energy each time one of them crossed, thus invalidating many of the interstitial binding energies.

The energy levels shown, however, demonstrated the meaning of a positive "binding energy". The numbers reflected the "amount of repulsion" associated with different positions in the lattice. The ordering of the levels, i.e., higher energies for deeper layers was expected. An interstitial deeper in the lattice felt more repulsion, because it was surrounded by a greater number of repulsive neighbors. Again, the level labeled " $\infty$ " represented an interstitial in a  $14 \times 14 \times 14$  lattice; but in this case of a Method 2 interstitial, crowdion migration did not occur.

The concept of a positive binding energy may or may not be the actual physical situation, but it is still academically valuable. Instead of an atom resting near the bottom of a potential well, as in Method 1, an atom can be "wedged" between the repulsive walls of its neighbors. In both cases, the atom is "bound" in the lattice. The ordering, spacing, and other correspondences between the positive and negative levels validate the qualitative use of the positive levels.

## 2. Replacement Impurities

A tungsten lattice with a replacement impurity is a perfect tungsten lattice, but Method 1 or Method 2 could be used on the atom in question. For Method 1, a perfect crystal was allowed to relax with time, yielding only negligible motion; and the





binding energies of the center atom in each layer was recorded (see Figure 1). The binding energies of atoms in the first, second, and third layers were -5.3 eV, -6.8 eV, and -7.0 eV respectively. The subsequent reversal of order for levels corresponding to deeper layers is a program anomaly, caused by the use of a finite depth crystal. Runs on larger crystals indicated that the order would not reverse in an infinite lattice. The " $\infty$ " level at -8.8 eV is the experimentally determined heat of sublimation [26] of tungsten. These numerical values for the binding energies were valid as standards of comparison for the Ne-W data, since the motion and equilibrium positions of the replacement atoms and their neighbors were nearly identical, and usually less than .3 LU in both cases. Note that the binding energies of the Method 1 replacement atoms were lower than the interstitial atom levels. As previously stated, this was to be expected, since a replacement atom rests in the bottom of a periodic potential well in the lattice, whereas an interstitial rests in a higher well, because it is nearer to its neighbors than the normal equilibrium separation. Also note that if the entire Method 1 spectrum of binding energy levels were used as a standard of comparison for Ne-W levels, then the W-W interstitial levels should be higher with respect to the replacement levels, than shown in Figure 1, because of crowdion migration.

The Method 2 replacement level labeled " $\infty$ " corresponded to a replacement atom in the center of the fifth layer in a 10 x 10 x 10 lattice. Note that it was not above the interstitial levels, as it should have been by comparison with Method 1. This



was the major weakness of Method 2: because it was a measure of repulsion only, and neglected the potential well, it underestimated the values of the binding energies of atoms whose normal position was in that well; i.e., replacement defects.

## E. THE NEON DEFECT IN TUNGSTEN

The neon atom defect was again placed in any one of the three lattice positions, labeled "int A", "int B", and "rep". The neon defect could be treated by Method 2 only. The neon energy levels are shown in Figure 2, on the next page. Note that the energies have been multiplied by a mass correction factor. (See Appendix D.)

### 1. Interstitials

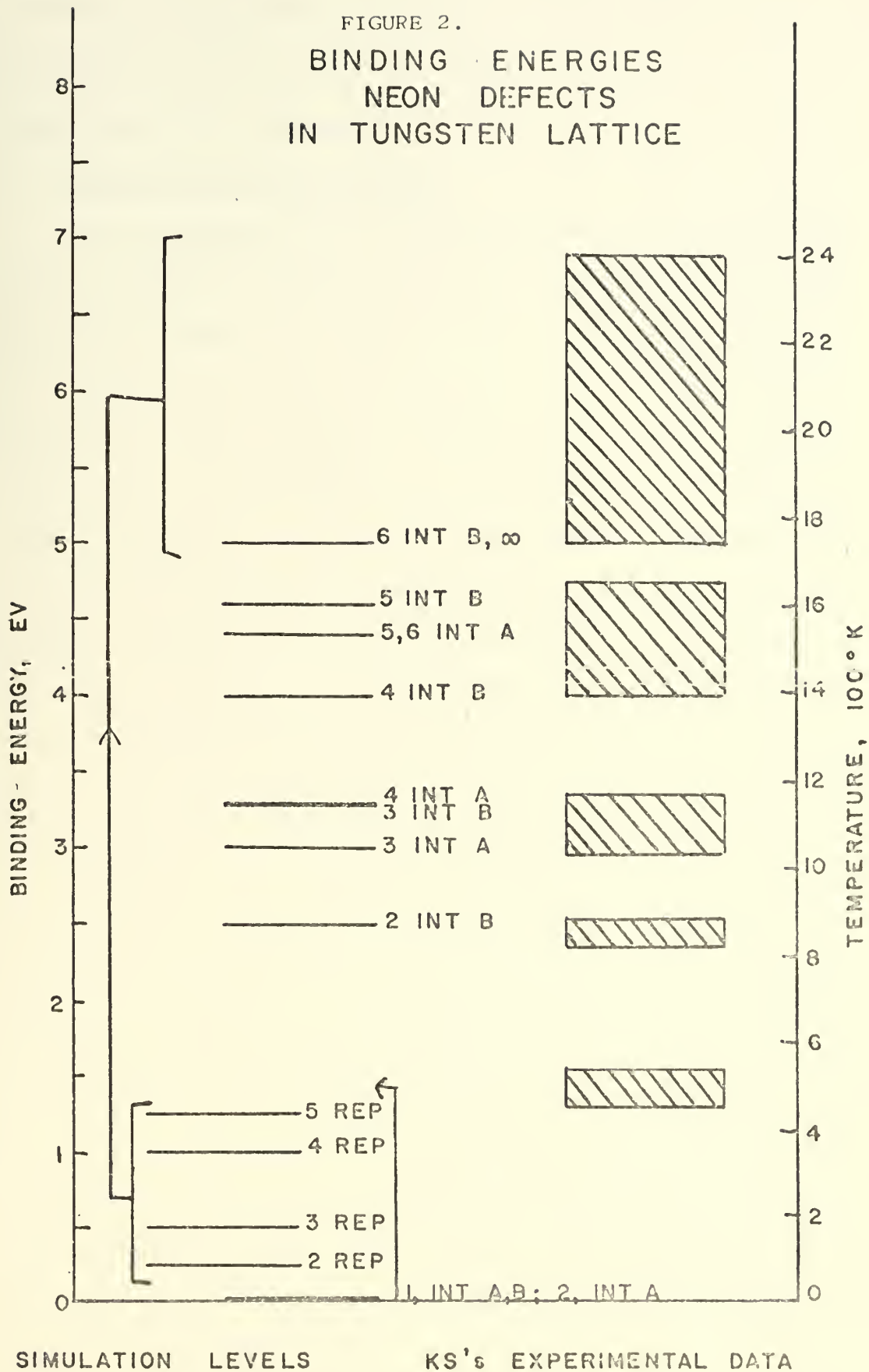
The neon interstitial never initiated crowdion migration, but as in the W-W case, atoms placed in the first two layers escaped the crystal, and therefore had zero binding energy. Again, the ordering of the levels was a measure of the repulsion on the interstitial, which increased as the interstitial was placed deeper in the lattice. Again the " $\infty$ " level was the result of placing a neon interstitial in the center of a  $14 \times 14 \times 14$  tungsten lattice.

### 2. Replacement Impurities

Again note that the replacement levels are lower than would be expected by comparison to the W-W Method 1 standard. It is hypothesized that these replacement levels should be higher than the interstitial levels, by comparison to the standard. This assumption is valid if a Ne-W potential well exists. It is feasible that since neon is almost incapable of binding, that no Ne-W well exists. On the other hand, the ionization state of both neon



FIGURE 2.  
 BINDING ENERGIES  
 NEON DEFECTS  
 IN TUNGSTEN LATTICE





and tungsten in the lattice is unknown, so the existence of a shallow potential well is quite possible.

## F. CORRELATION WITH EXPERIMENT

### 1. Scaling the Levels and Peaks

Since no direct way of transforming the Ne-W energy levels into correctly scaled negative values exists, an arbitrary linear scaling factor between KS's data and the Ne-W levels has been used. Note that every level or group of levels corresponded to an experimental peak in Figure 2, except in two places: first, the broad peak at about  $2000^{\circ}$  K had no energy level counterpart, but could be assumed to correspond to the closely ordered replacement levels, shifted above the interstitial levels by the above hypothesis. Second, the narrow peak at  $450^{\circ}$  K was without an energy level counterpart. Note that three interstitial levels had zero simulated binding energy because they had escaped the crystal. If, however, the assumption that a Ne-W well exists was true, then some or all of these three interstitial locations, (i.e., two surface layer positions and the open channel position in the second layer) would be stable, bound positions, and would be expected to generate an energy level in the vicinity of the  $450^{\circ}$  K peak. If the arbitrary scaling of the peaks and levels was correct, then the peak at  $450^{\circ}$  K is proof that a Ne-W well exists, since a purely repulsive potential would not allow a first layer or second layer open channel interstitial energy level to exist. The existence of this well, then, would in turn substantiate the shift of the replacement levels above the interstitial levels, to correspond to the  $2000^{\circ}$  K peak.





## 2. Probes of Potential Wells

Various attempts to substantiate the scaling between the levels and peaks were made. No approximation to a Ne-W potential well could be justified, and the correspondence between W-W and Ne-W results was not complete enough to invert and scale the potential energy levels to realistic, negative, binding energies.

Attempts were also made to match both Method 1 and Method 2 W-W energy levels to KS's data. The Method 2 levels were too incomplete, and the Method 1 levels required an unknown arbitrary reduction of interstitial energy levels to compensate for crowdion migration. Too many alternate reductions were possible to choose one as the correct rescaling.

Another approach that yielded little information was a plot of the differences between interstitial and replacement energy levels for each layer in the lattice.

One valuable method of investigating the nature of possible Ne-W negative binding energies was to probe the perfect lattice with an interstitial at various initial positions and plot the resultant potential energy of an interstitial vs. position. Since the potential was always positive, the results of this investigation were potential wells above the x-axis. Although the positive location of these wells was not realistic, the relative depth of the wells was significant. The average depth of a neon interstitial well, deep in the lattice, was about 4.2 eV (see Figure 8). The graph was made by placing interstitials in positions in the  $\langle 010 \rangle$  open channel, and thus represents the barriers that the interstitial must penetrate as it escapes the crystal. Note that the wells were not at the obvious holes in the BCC lattice, but were between layers.



In the actual simulation, the interstitial rarely fell into this well, but instead pushed its two nearest neighbors away and made the initial position the low potential position. Here again, surface effects and relaxation reduced the tendency for interstitials to relax into expected infinite lattice equilibrium positions. Slight differences in the final equilibrium positions were not of significant importance to binding energies. The actual numerical values for the depths of these positive wells were not necessarily scaled properly since they ignored the actual Ne-W potential well, and were found from perfect lattice probes at time zero, before relaxation. Nevertheless, the depth of a well deep in the lattice of 4.2 eV agreed well with KS's prediction of 4.5 eV [8] for the desorption energy corresponding to 1720<sup>o</sup>K, at the front edge of the highest peak. 1720<sup>o</sup> K closely approximated the temperature that the arbitrary scaling had assigned to a deep interstitial.

Note that the initial position of a replacement atom was  $\sqrt{3}$  l.u from its neighbors, and thus because of potential erosion, it had a potential of zero eV initially. To climb out of this well, about 17.5 eV must be supplied. Although this number was inaccurate for the same reasons listed above, it did demonstrate that even a purely repulsive potential can predict a greater binding energy for replacement atoms than for interstitial atoms.



## V. CONCLUSIONS

An arbitrary scaling has been used to correlate the simulation results with experimental data. Although the method was not analytically sound, no other avenues of approach to the problem could be found that could further justify our hypothesis.

Satisfaction can be gained, however, from the fact that these results compare favorably with known data at many interfaces. Our model was a tried and proven one, with many successful sputtering, channelling, and similar simulations to its credit. This present model invariably behaved in a physically valid manner or a manner which could be made physically acceptable by varying the controlling parameters in the program. Specifically, many previous experimental and simulated results for infinite crystals were reproduced when simulation took place deep in a large lattice, such as the  $\langle 110 \rangle$  split interstitial position for BCC structures. The Method 1 replacement levels, if found for a much deeper crystal, would have asymptotically approached very close to the 8.8 eV heat of sublimation. The simulated depth of the positive potential well for interstitials of about 4.2 eV closely approximated KS's prediction of 4.5 eV.

All avenues in additional computer simulation have not been exhausted. Future simulation of Argon, Krypton, and Xenon defects in tungsten should be fruitful. Comparisons between the relative locations of these new energy levels might further substantiate this research. In particular, if simulation can explain why KS's neon data contains five desorption peaks, while their Argon, Krypton, and Xenon data contain four peaks, it will be a major



success. KS also gathered data for different crystal surfaces and different angles of incidence, which might be investigated by computer simulation.

This simulation was also important in that it investigated the lattice surface; a topic which has not received as much attention as infinite crystal dynamics. Since radiation damage theory and modern transistor theory is very much concerned with the crystal surface, the computer simulation field will undoubtedly increase their emphasis on surface effects, with considerable attention toward better ways of treating a foreign interstitial.

A new exhaustive book which reports on the present state of knowledge in all these areas, with emphasis on experimental results has just been published. It is a report on the proceedings of the International Conference on Vacancies and Interstitials in Metals, 1968 [27].





## APPENDIX A: CRYSTAL GEOMETRY

The computer program can call any one of nine lattice generator subroutines: three face-centered cubic subroutines ([L100], [L110], [L111]), three body-centered cubic subroutines ([B100], [B110], [B111]), and three diamond subroutines ([D100], [D110], [D111]). The diamond subroutines are never used and therefore not compiled; but provision has been made for their future inclusion in the program. The dimensions of the lattice chosen were controlled by the input data variables [IX], [IY], and [IZ]. Each atom in the crystal was numbered, in the order x followed by z, followed by y. For the surface layer ( $Y = 0$ ) of the tungsten  $10 \times 10 \times 10$  lattice, atoms were numbered from 2-26; for the first layer below the surface, atoms were numbered 27-51, etc. Atom number 1 was the primary, or point defect atom. [LD] was the number of the last mobile atom, or the last atom in the eighth layer, number 200; and [LL] was the number of the last atom in the crystal, number 250.

The placement of point defects was accomplished as follows: after the desired perfect lattice was built to the desired size, subroutine PLACE was called. Three types of defects were allowed: vacancies, interstitials, and replacement impurities. The type and location of the defect were controlled by input data variables: the type of defect [ITYPE], an atom number [NVAC] and a displacement vector [D1X, D1Y, D1Z] in LU. If [ITYPE] = 1, a vacancy was created in site number [NVAC]. This "removal" was accomplished by setting [LCUT (NVAC)] = 1 which "turned off" the atom, removing it from all calculations. If [ITYPE] = 2, an interstitial was created in a position [-D1X, -D1Y, + D1Z] LU from



site number [NVAC]. This interstitial was always atom number 1. Since atom number 2 was always at the origin, number 1 could be placed using a displacement vector from the origin (from [NVAC] = 2) or using a displacement vector from a site next to the interstitial. If [ITYPE] = 3, a vacancy was created in site number [NVAC] and a replacement impurity, put in its place. Note that for both [ITYPE] = 2 and 3, either a foreign or self defect could be placed. For the case of either the self-interstitial or the self-replacement atom (giving us back the perfect crystal), either method 1 or method 2 of calculating the potential could be used. The choice of methods was also an input parameter: for method 1, [IQ] = 1, and for method 2, [IQ] = 2.



## APPENDIX B: POTENTIALS

(In this appendix and all subsequent appendices, the brackets denoting program language are dropped. Program language is still written in all capital letters.)

### A. BORN-MAYER REPULSIVE POTENTIAL

1. Potential Energy: For the lattice atom interactions, the Born Mayer potential equation is:

$$V_{ij} = \exp(A + Br_{ij}) \quad (1)$$

or

$$POT = EXP(EXA + EXB*DIST) \quad (1A)$$

For bullet-lattice atom interactions,

$$V_{ij} = \exp(A' + B'r_{ij}) - V_{ij}(ROE) \quad (3)$$

where  $V_{ij}(ROE)$  is subtracted to retard the potential so that it goes to zero at the nearest neighbor distance. in the program, the  $V_{ij}$  equation is:

$$POT = EXP(PEXA + PEXB*DIST) - PPTC \quad (3A)$$

2. Force: For the lattice atom interaction,

$$\begin{aligned} \text{Force} &= \frac{-\partial V_{ij}}{\partial r_{ij}} = -B \exp(A + Br_{ij}) \\ &= \exp [(\ln -B + A) + Br_{ij}] \end{aligned} \quad (4)$$

in the program,  $\ln(-B + A) = (ALOG[-EXB*CVED] + EXA) = FXA$ , where CVED is a conversion factor for units, and

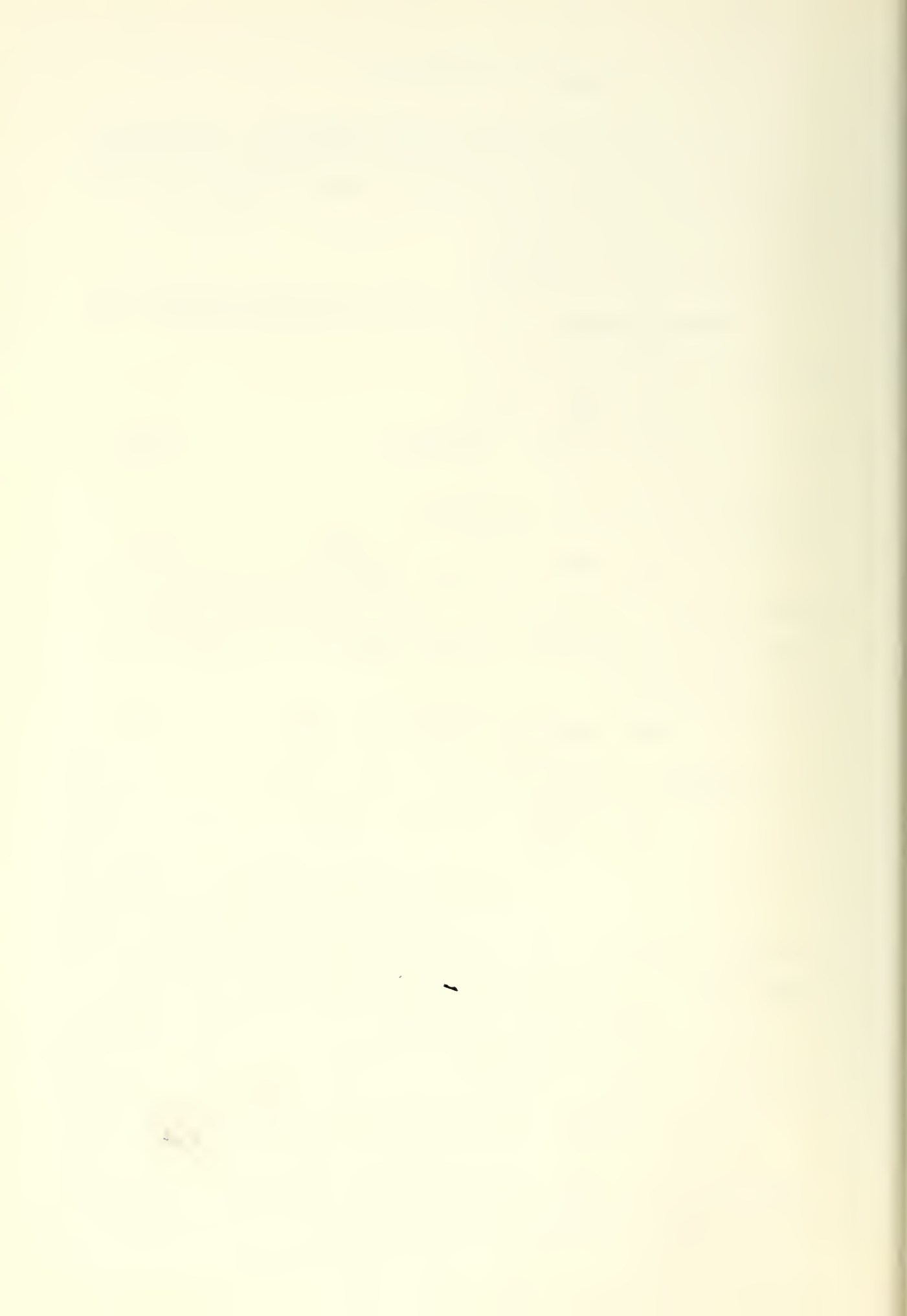
$$FORCE = [FXA + EXB*DIST] \quad (4A)$$

For bullet-lattice atom forces,

$$\text{Force} = \frac{-\partial V_{ij}}{\partial r_{ij}} = -B' \exp(A' + B'r_{ij}) = \exp[(\ln -B' + A') + B'r_{ij}] \quad (5)$$

where  $(\ln -B' + A') = (ALOG[-PEXB*CVED] + PEXA) = PFXA$ , and

$$FORCE = EXP[PFXA + PEXB*DIST] \quad (5A)$$



For bullet-lattice atom forces for which lattice atoms enter the range of the bullet's force during the timestep, a first approximation to the force is given by:

$$\text{Force} = \frac{V_{ij} - V_{ij}(\text{ROE})}{r_{ij} - \text{ROE}} \quad (6)$$

(See Figure 9).  $V_{ij} - V_{ij}(\text{ROE})$  is the retarded potential given above. A conversion factor is needed to preserve the proper units, so the following substitutions are made in the retarded potential equation (3A): (PEXA) becomes  $(2n \text{ CVED} + \text{PEXA}) = \text{PAC}$ , so  $V_{ij} = \text{EXP}[\text{PAC} + \text{PEXB} * \text{DIST}]$ , and  $V_{ij}(\text{ROE}) = \text{PPTC}$  becomes  $\text{PFPTC}$ , which is  $V_{ij}(\text{ROE})$  calculated after the PAC substitution. Finally,  $r_{ij} - \text{ROE} = \text{DIST} - \text{ROE} = \text{DFE}$ , and

$$\text{FORCE} = \frac{(\text{EXP}[\text{PAC} + \text{PEXB} * \text{DIST}] - \text{PFPTC})}{\text{DFE}} \quad (6A)$$

Note: (5A) is used for  $0 \leq \text{DIST} \leq \text{ROE} - \text{DT1} = \text{ROEM}$ , and (6A) is used for  $\text{ROEM} < \text{DIST} < \text{ROE}$ .

## B. MORSE POTENTIAL

1. Potential Energy: For lattice atom interactions, the Morse potential equations is:

$$\phi_{ij} = D \left[ \exp\{-2\alpha(r_{ij} - r_o)\} - 2\exp\{-\alpha(r_{ij} - r_o)\} \right] \quad (2)$$

$$= \exp[(\ln D + 2\alpha r_o) - (2\alpha)r_{ij}] - \exp[(\ln(2D) + \alpha r_o) - (\alpha)r_{ij}]$$

$$= \text{EXP}[(\text{ALOG}(\text{DCON}) + 2.*\text{ALPHA}*\text{RE}) - (2.*\text{ALPHA}*\text{CVR})*\text{DIST}]$$

$$- \text{EXP}[(\text{ALOG}(2.*\text{DCON}) + \text{ALPHA}*\text{RE}) - (\text{ALPHA}*\text{CVR})*\text{DIST}]$$

$$= \text{EXP}[\text{CGD1} - \text{CGB1}*\text{DIST}] - \text{EXP}[\text{CGD2} - \text{CGB2}*\text{DIST}] \quad (2A)$$

2. Force: For lattice atom interactions,

$$\text{Force} = \frac{-\partial \phi_{ij}}{\partial r_{ij}} = D \left[ 2\alpha \exp\{-2\alpha(r_{ij} - r_o)\} - 2\alpha \exp\{-\alpha(r_{ij} - r_o)\} \right]$$





$$\begin{aligned}
&= \exp[\ln(2\alpha) + (\ln D + 2\alpha r_o) - (2\alpha) r_{ij}] - \exp[\ln \alpha + (\ln(2D) + \alpha r_o) - (\alpha) r_{ij}] \\
&= \text{EXP}[\text{ALOG}(2 * \text{ALPHA} * \text{CVR} * \text{CVED}) + \text{ALOG}(\text{DCON}) + 2. * \text{ALPHA} * \text{RE} \\
&\quad - (2. * \text{ALPHA} * \text{CVR}) * \text{DIST}] \\
&- \text{EXP}[\text{ALOG}(\text{ALPHA} * \text{CVR} * \text{CVED}) + \text{ALOG}(2. * \text{BCON}) + \text{ALPHA} * \text{RE} \\
&\quad - (\text{ALPHA} * \text{CVR}) * \text{DIST}] \\
&= \text{EXP}[\text{ALOG}(-\text{CGB1} * \text{CVED}) + \text{CGD1}] - \text{CGB1} * \text{DIST}] \\
&\quad - \text{EXP}[(\text{ALOG}(-\text{CGB2} * \text{CVED}) + \text{CGD2}) - \text{CGB2} * \text{DIST}] \\
&= \text{EXP}[\text{CGF1} - \text{CGB1} * \text{DIST}] - \text{EXP}[\text{CGF2} - \text{CGB2} * \text{DIST}] \quad (7A)
\end{aligned}$$

### C. CUBIC FIT

1. Potential Energy: The best cubic fit between the EM and Morse potentials is calculated in Subroutine CROSYM. The potential equation, defined between ROEA and ROEB, is

$$\text{POT} = \text{CP3} r_{ij}^3 + \text{CP2} r_{ij}^2 + \text{CP1} r_{ij} + \text{CP}\emptyset \quad (8)$$

or 
$$\text{POT} + \text{DIST} * (\text{DIST} * (\text{DIST} * \text{CP3} + \text{CP2}) + \text{CP1}) + \text{CP}\emptyset \quad (8A)$$

2. Force: 
$$\text{Force} = \frac{-\partial \text{POT}}{\partial r_{ij}} = -3\text{CP3} r_{ij}^2 - 2\text{CP2} r_{ij} - \text{CP1} \quad (9)$$

$$= (-3. * \text{CP3} * \text{CVED}) r_{ij}^2 + (-2. * \text{CP2} * \text{CVED}) r_{ij} + (-\text{CP1} * \text{CVED})$$

$$= \text{CF2} r_{ij}^2 + \text{CF1} r_{ij} + \text{CF}\emptyset, \text{ or}$$

$$\text{FORCE} = \text{DIST} * (\text{DIST} * \text{CF2} + \text{CF1}) + \text{CF}\emptyset. \quad (9A)$$



## APPENDIX C: AVERAGE FORCE METHOD AND TIME DURATION THEORY

A. AVERAGE FORCE METHOD: The average force technique has been explained in great detail in Ref. 15. It was summarized in Chapter 3, and therefore discussion here is limited to the average force method in the program language.

When the desired lattice is built, the position of the ith atom is stored simultaneously in RX(I), RY(I), RZ(I); RXK(I), RYK(I), RZK(I); and RXI(I), RYI(I), RZI(I). The latter set of coordinates never change and are used for comparing new positions to original positions, and in calculating DX(I), DY(I) and DZ(I) for output. The middle set of coordinates containing the letter K are for storing the initial positions at the beginning of each timestep. A step by step summary of the average force method, showing X coordinate calculations only, follows:

1. Based on the position, RX(I), of the ith particle at the beginning of the timestep, the force FX(I) is calculated in STEP.
2. RX(I) is stored in RXK(I).
3. The new, temporary position, RX(I) is calculated, based on the force at RXK(I):

$$X^1 = X + V\Delta t + F(\Delta t)^2/2m \quad (10)$$

or

$$RX(I) = RX(I) + DTOD * (HDTOM * FX(I) + VX(I)). \quad (10A)$$

4. A new force is calculated, based on this new position RX(I).
5. VSS stores VX(I), the original velocity of the ith atom. This velocity is half the velocity of the ith atom in the previous timestep: the  $\frac{1}{2}$  factor being an arbitrary damping multiplier. A



new velocity, based on the new force, is found:

$$V^1 = V + F\Delta t/2m \quad (11)$$

or

$$VX(I) = VSS + HDTOM * FX(I). \quad (11A)$$

6. The final position is calculated, based on the average of these two velocities

$$X^1 = X + \frac{1}{2}\Delta t(V + V^1) \quad (12)$$

or

$$RX(I) = RXK(I) + (VX(I) + VSS) * HDTOD \quad (12A)$$

The resultant velocities are halved, a new timestep duration is calculated, and the process repeated.

#### B. TIMESTEP DURATION THEORY

This simulation uses the best possible estimate of a timestep duration, DT, as calculated from the present state of the forces and energies in the lattice for use in the next timestep. To limit motion to an increment small enough to preserve the accuracy of the average force approximation, we define DTI as the maximum distance any atom is allowed to move in one timestep.

From (10), we find

$$\Delta X_i = (V_i + F_i \Delta t / 2m) \Delta t.$$

Therefore,

$$\Delta t = \Delta X_i / (V_i + F_i \Delta t / 2m). \quad (13)$$

For

$$V_i \gg F_i \Delta t / 2m, \quad \Delta t \approx \Delta X_i / V_i. \quad (14)$$

If we find the fastest moving atom and assure that it does not move more than DTI, we have limited the motion of all other atoms to less than DTI.

Thus,

$$DT = (DTI * CVD) / EMAX = FDTI / EMAX \quad (14A)$$



where

$$EMAX = \text{SQRT}(VX(I)*VS(I)+VY(I)*VY(I)+VZ(I)*VZ(I)).$$

For  $V_i \gg F_i \Delta t / 2m$ ,

$$\Delta t = \Delta X_i / F_i \Delta t / 2m = \frac{2m \Delta X_i}{F_i} . \quad (15)$$

Anatagous to above, we find the most stressed atom and assure that it does not move more than DTI. Thus,

$$\begin{aligned} DT &= \text{SQRT}[(2.*PTMAS*DTI*CVD)/FMAX] \\ &= \text{SQRT}[TFAC/FMAX] \end{aligned} \quad (15A)$$

where  $FMAX = \text{SQRT}[FX(I)*FX(I)+FY(I)*FY(I)+FZ(I)*FZ(I)]$ .

Since rigorously we cannot make either or these limiting assumptions, we must go back to our original equation for DT, equation (13).

Since this equation involves DT, we proceed as follows:

1. Assume  $V_i \ll F_i \Delta t / 2m$  and calculate  $\Delta t$  from (15A).
2. Insert this preliminary value for DT in (13) and compare  $V_i$  to  $F_i \Delta t / 2m$ . If  $V_i$  is larger, calculate DT from (14A). If  $F_i \Delta t / 2m$  is larger calculate DT from (15A).

A complication arises when a foreign impurity is in the lattice, because of a variation in the value for m in (15). This is especially acute when the differences in masses are great. The method used to solve this problem is as follows:

1. If either  $FMAX = F_1$  or  $EMAX = V_1$ , the entire procedure, above, is followed using the mass of the bullet for m.
2. If both  $FMAX \neq F_1$  and  $EMAX \neq V_1$ , the entire procedure is followed using the mass of a lattice atom.

The requirement that the bullet mass be used if either EMAX or FMAX describe the bullet circumvents the problem of having the





bullet the fastest moving atom, but not the most stressed atom,  
or visa versa.

To begin the problem, an arbitrary value of  $10^{-14}$  seconds is  
assigned to DT. If at any time in the program  $EMAX = FMAX = \text{zero}$ ,  
 $10^{-14}$  is again assigned to DT to prevent division by zero.



## APPENDIX D: SUBROUTINES STEP, ENERGY, AND LOCAL

### A. DISTANCE CALCULATIONS

In all three subroutines, STEP, ENERGY, and LOCAL, a method of finding all atoms within a given radius of another atom was needed. For lattice atom interactions, atoms inside ROEA, ROEB, and ROEC were found; for the foreign interstitial interactions, atoms inside ROE were found; and for LOCAL, atoms inside ROEL of a point defect were found. The time saving technique used to do this was to successively eliminate all atoms with an x component difference greater than the given radius, then similarly for y components, then for z components. The resulting volume not eliminated is a cube circumscribing the desired sphere. Finally the time-consuming test of eliminating all atoms for which the desired radius is less than  $\text{SQRT}(\text{DRX}^2 + \text{DRY}^2 + \text{DRZ}^2)$  is applied to only atoms inside the cube.

### B. SUMMATION INDICES IP AND IQ

Interactions  $V_{ij}$ ,  $\phi_{ij}$ , and  $F_{ij}$  are found by evaluating all values in the half matrix. For example  $F_{12}$ ,  $F_{13}$ ,  $F_{14}$  ... are found, then  $F_{23}$ ,  $F_{34}$ , ... etc. The variable IP controls the starting point for the j summation. IP is always set to I + 1 to avoid the repetition of finding  $F_{ij}$  and  $F_{ji}$ . IQ controls the starting point for the i summation. If the primary is to be treated as a lattice atom, IQ = 1. If it is to be treated as a foreign particle, IQ = 2, and all  $F_{ij}$  are found separately.

### C. DISTRIBUTION OF FORCES AND POTENTIAL ENERGIES

The forces  $F_{ij}$  are equal and opposite on i and j: i.e.,  $F_i = -F_j$ . The potential energies are split in proportion to the reduced



mass of the interacting particles. This is easily understood by observing the kinetic energy distribution of an elastic collision of  $m$  and  $M$  where  $M > m$ . We find that  $m$  carries away almost all the kinetic energy: specifically it carries away  $\left(\frac{M}{m+M}\right) E_{TOT} \sim E_{TOT}$ . If a pair of atoms are to behave elastically, the potential energies which are transformed into kinetic energies of motion must be split in the same manner. For this reason,

$$PPE(1) = \left(\frac{TMAS}{TMAS+EMAS}\right) * POT = BSAVE * POT;$$

and

$$PPE(J) = \left(\frac{EMAS}{TMAS+EMAS}\right) * POT = TSAVE * POT.$$

note, for  $EMAS = TMAS$ ,  $BSAVE = TSAVE = \frac{1}{2}$ , and the energies are split equally.

#### D. SUBROUTINE LOCAL

LOCAL measures the change in potential energy associated with a sphere of radius ROEL surrounding a point defect. It sums up the potential energies of each atom found inside this sphere at time zero. It remembers these atoms, and for each timestep re-sums the potential energies of these same atoms. The sum, total local potential energy TLPE, is subtracted from TLPE at time zero (TLPE $\delta$ ), to give a measure of the change in potential energy (DLPE) inside ROEL.



## APPENDIX E: COMPUTER PROGRAM GLOSSARY

NOTE: In this glossary, the terms "point defect atom", "bullet", and "primary" are synonymous; and the terms "lattice atom" and "target" are synonymous.

ALPHA: Input Morse potential parameter

BSAVE: Target mass/(target mass + bullet mass); distributes potential energy between target and bullet

BIND: Negative of the total potential energy (TPOT) at time zero

BMAS: Mass of bullet in amu

BULLET: Alpha-numeric array for point defect material

CFO, CF1, CF2: Force parameters of cubic fit between Morse and Born-Mayer functions

CGB1, CGB2: Morse potential parameters

CGD1, CGD2: Morse potential parameters

CGF1, CGF2: Morse force parameters

CPO, CP1, CP2, CP3: Potential parameters of cubic fit between Morse and Born-Mayer functions

CVD:  $CVR \times 10^{-10}$ , converts lattice units to meters

CVE:  $1.6 \times 10^{-19}$ , converts electron volts to joules

CVED:  $CVE/CVD$ , a ratio used to avoid repeated division

CVM:  $1.672 \times 10^{-27}$ , converts atomic mass units to kilograms

CVR: LU in angstroms; converts lattice units to angstrom units

DLX, DLY, DLZ: Displacement coordinates for location of interstitial from reference atom, NVAC

DCON: Input Morse potential parameter

DFF: ROE-DIST, the distance closer than ROE that an atom is to the primary





DIST: Distance between any two atoms

DLPE:  $TLPE - TLPE_0$ , the change in total local potential energy since time zero

DRX, DRY, DRZ: x,y,z components of DIST

DT: Length of a timestep in seconds

DTI: Number of lattice units most energetic atom may move in one timestep

DTOD:  $DT/CVD$ --a ratio used to avoid repeated division

DTOM:  $DT/PTMAS$ --a ratio used to avoid repeated division

DTOMB:  $DT/PEMAS$ --a ratio used to avoid repeated division

DX(I), DY(I), DZ(I): Change in position of ith atom from initial position at time zero

EMAX: The maximum energy encountered in any cycle

EV: Primary energy in electron volts

EVR: Primary energy in kilo-electron volts

EXA, EXB: Input Born-Mayer potential function parameters for the target

F2: Square of the force on a specific atom

FA: The component force increment on an atom

FDTI:  $DTI \times CVD$ , a parameter used to determine DT my maximum energy method

FM: A small number used in checking potential energy zero point

FM2: FM squared

FMAX: Maximum total force on the most stressed atom in the crystal

FOD:  $FORCE/DIST$ --a ratio used to avoid repeated division



FORCE: Numerical value of the force function with a variable  
 parameter

FX(I), FY(I), FZ(I): x,y,z components of total force on an atom

FXA: Born-Mayer force function parameter

HBMAS:  $\frac{1}{2}$  BMAS--a ratio used to avoid repeated division

HDTOD:  $\frac{1}{2}$  DTOD--a ratio used to avoid repeated division

HDTOM:  $\frac{1}{2}$  DTOM--a ratio used to avoid repeated division

HDTOMB:  $\frac{1}{2}$  DTOMB--a ratio used to avoid repeated division

HTMAS:  $\frac{1}{2}$  TMAS--a ratio used to avoid repeated division

I1: Variable in cubic fit subroutine

I3: " " " " "

IDEEP: Number of mobile layers

IH1: Alpha numeric array for program title

IH2: " " " " Morse function parameters

IHB: " " " " bullet element

IHS: " " " " type and orientation of crystal

IHT: " " " " target element

ILAY: Same as IDEEP

IN: Odd-even integer used to determine atom site establishment

IP: Subscript value of atom. Used in subroutines STEP and  
 ENERGY

IQ: Parameter that determines whether or not a self defect is  
 to be given a repulsive potential or a composite attractive-  
 repulsive potential

ISHUT: A parameter used to shut down the program

IT: Unscaled fixed point x coordinate used in lattice generation

ITT: Odd-even integer used to determine atom site establishment



ITYPE: Parameter used to determine the type of point defect:  
         vacancy, interstitial, or replacement

IX, IY, IZ: Number of x,y,z planes of crystal

J2: Variable in the cubic fit subroutine

JJ: Parameter in the BCC(111) lattice generation subroutine

JT: Unscaled y coordinate used in crystal generation

JTS: Variable used to establish atom sites

JTT: " " " " " "

KF: Final K in LOCAT (K) assigned to an atom

KT: Unscaled z coordinate used to establish atom site

LCUT(I): Used to identify an ith atom which is not included in  
           calculations

LD: The highest numbered atom in the mobile layers

LL: The highest numbered atom in the entire crystal

LOCAT(K): Dimensioned variable that remembers the numbers of the  
           atoms within a radius ROEL of the primary at time zero

LS: Variable associated with each of the nine lattice  
       generator subroutines

MCRO: One number higher than the order of the fit between the  
       Born-Mayer and Morse potentials, always 4 in this simu-  
       lation

ND: Data output increment, in numbers of timesteps

NEW: Parameter used to determine whether or not atom numbers  
       have been stored in LOCAT(K)

NPAGE: Page numbering variable

NRUN: Parameter used to determine whether or not to read  
       additional data cards



NS: Initial print statement timestep number

NT: Timestep number

NTT: Timestep number limit before shutdown

NVAC: An atom number used to establish point defects or used as a reference point for interstitial placement

PAC: Parameter for bullet force function correction

PBMAS: Primary mass in kilograms

PEXA, PEXB: Input Born-Mayer potential function parameters for the bullet-target interaction

PFPTC: Primary force function evaluated at ROE

PFXA: Primary force function parameter

PKE(I): Kinetic energy of the ith atom

PLANE: Alpha-numeric array for lattice orientation

POT: Potential energy between two atoms

PPE(I): Potential energy of the ith atom

PPTC: Primary potential function evaluated at ROE

PTE(I): Total energy of the ith atom (potential + kinetic)

PTMAS: Target mass in kilograms

RE: Input Morse potential parameter

RO: Spacing constant in FCC(110) lattice generation subroutine

ROE: Nearest neighbor distance

ROE2: ROE squared

ROEA: Maximum cut off for Born-Mayer potential

ROEB: Minimum cut off for Morse potential

ROEC: Maximum cut off for Morse potential

ROEC2: ROEC squared

ROEL: Radius inside of which local potential energy is found





ROEL2: ROEL squared

ROEM: ROE-DTI, region in which modification of repulsive force must be made

RX(I), RY(I), RZ(I): x,y,z coordinates of an ith atom at any time

RXI(I), RYI(I), RZI(I): x,y,z coordinates of an ith atom's initial position

RXK(I), RYK(I), RZK(I): x,y,z coordinates of temporary position of an ith atom during force cycle

SAVE:  $\frac{1}{2}$  POT

SCX, SCY, SCZ: x,y,z coordinate scale factors

SSCZ: A z scale factor used for the FCC(111) lattice generator subroutine

START: An optional timing variable, not used in this simulation

SUM: Variable in cubic fit subroutine

TARGET: Alpha-numeric array for target material

TSAVE: Bullet mass/(target mass + bullet mass); distributes potential energy between target and bullet

TE: Total energy of all crystal atoms (kinetic + potential)

TEMP: Temperature of lattice in degrees Kelvin. Not used in this simulation

TFAC: A time factor ratio used to determine DT by maximum force method

TFACB: TFAC for the bullet

THERM: Thermal energy of atom. Not used in this simulation

TIME: Elapsed problem time in seconds

TLPE: Total local potential energy of atoms within a radius ROEL

TLPE $\emptyset$ : TLPE at time zero



TMAS: Target atom mass in amu  
TPKE: Total kinetic energy of all crystal atoms  
TPOT: Total potential energy of all crystal atoms  
VSS: Storage variable for velocity components  
VX(I), VY(I), VZ(I): x,y,z components of ith atoms velocity  
X, Y, Z: Unscaled coordinates used in crystal generation  
YLAX(I): Relaxation in -y direction of ith layer in L.U.  
ZP: Floating point form of JTT



FIGURE 3.  
 TUNGSTEN-TUNGSTEN  
 COMPOSITE POTENTIAL  
 VS.  
 SEPARATION

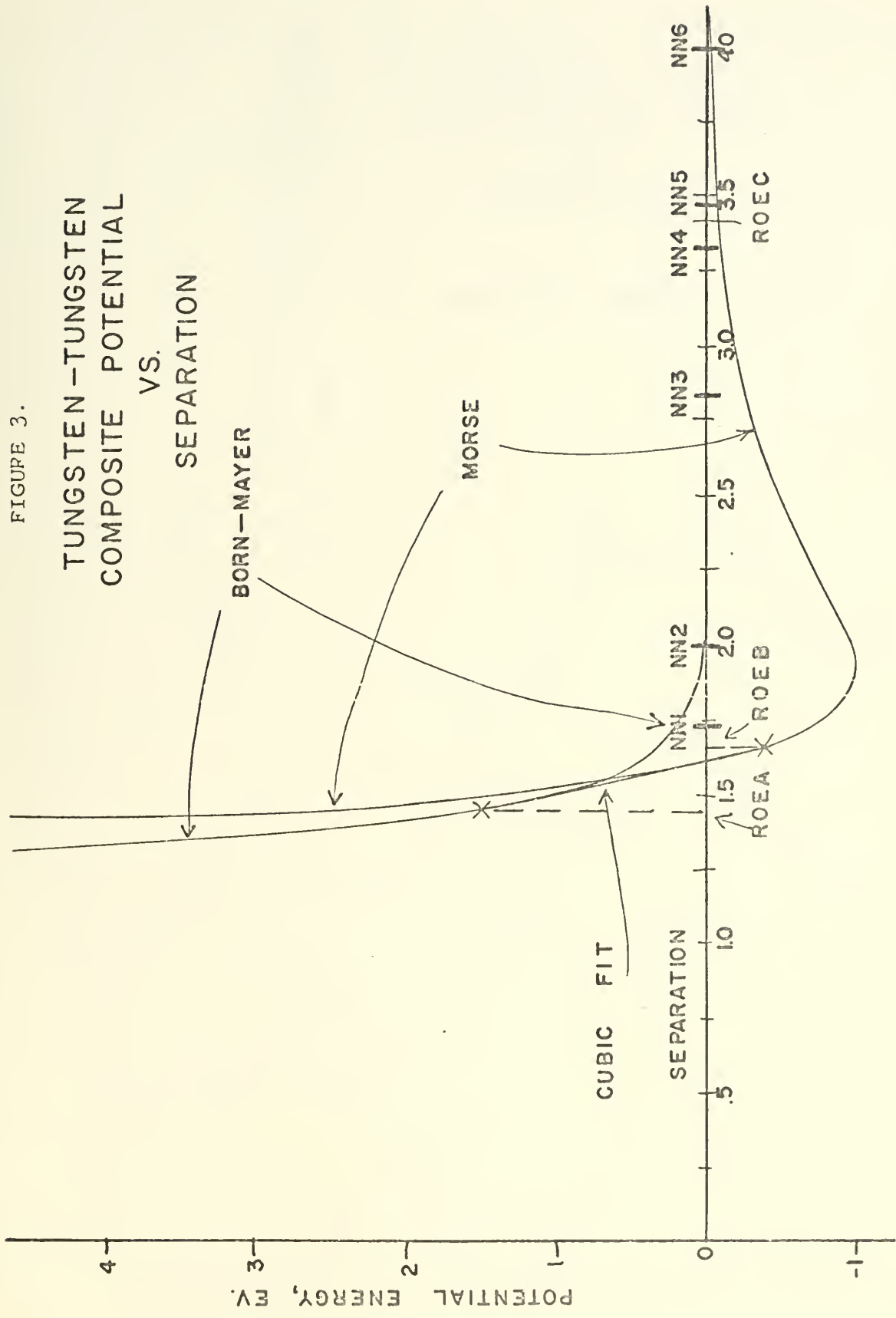




FIGURE 4.  
TUNGSTEN (100)  
DESORPTION RATE  
VS.  
TEMPERATURE

ION INCIDENCE ENERGY: 600 ev.

DESORPTION RATE (LINEAR SCALE)

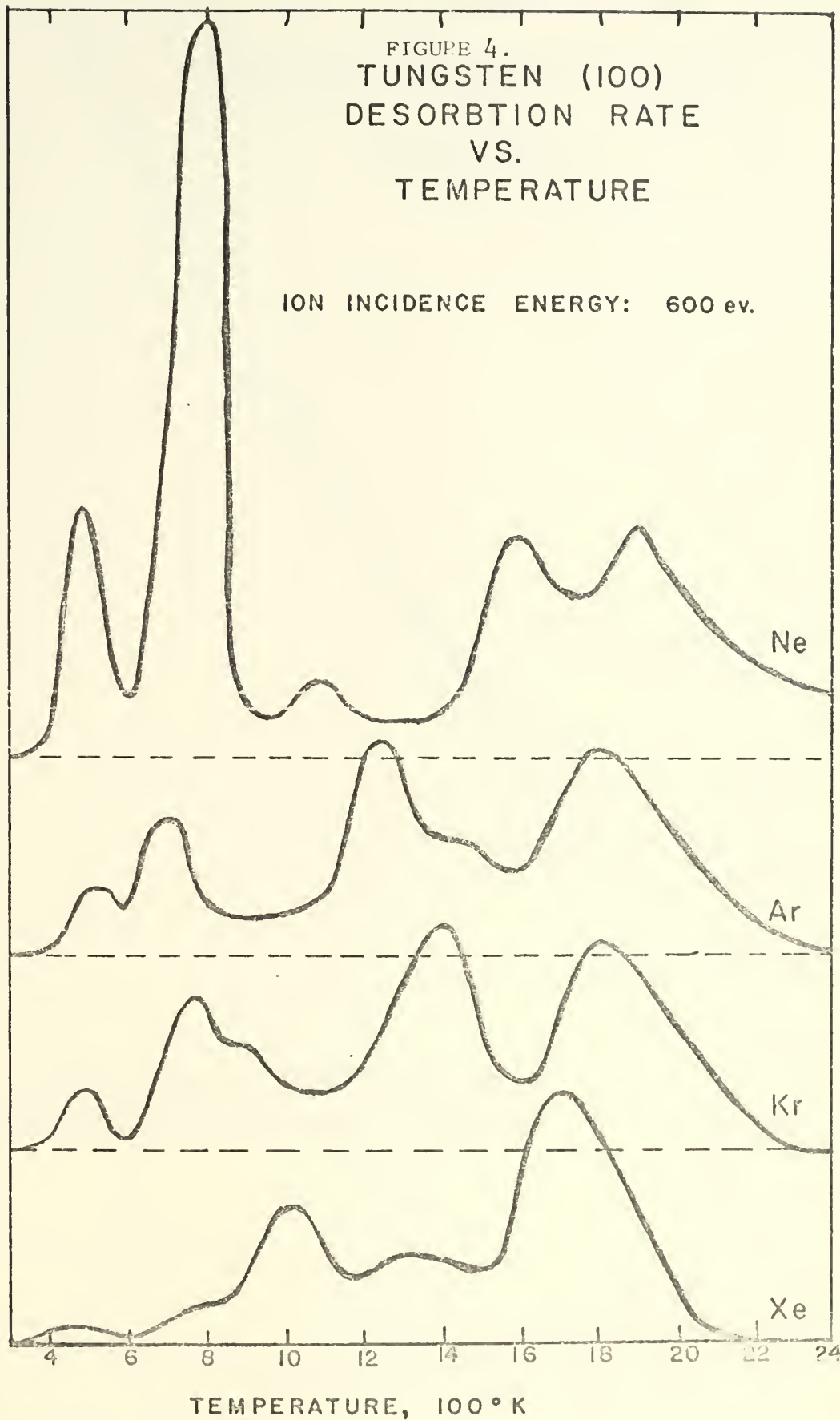






FIGURE 5.  
REPULSIVE POTENTIAL ENERGY  
VS.  
SEPARATION

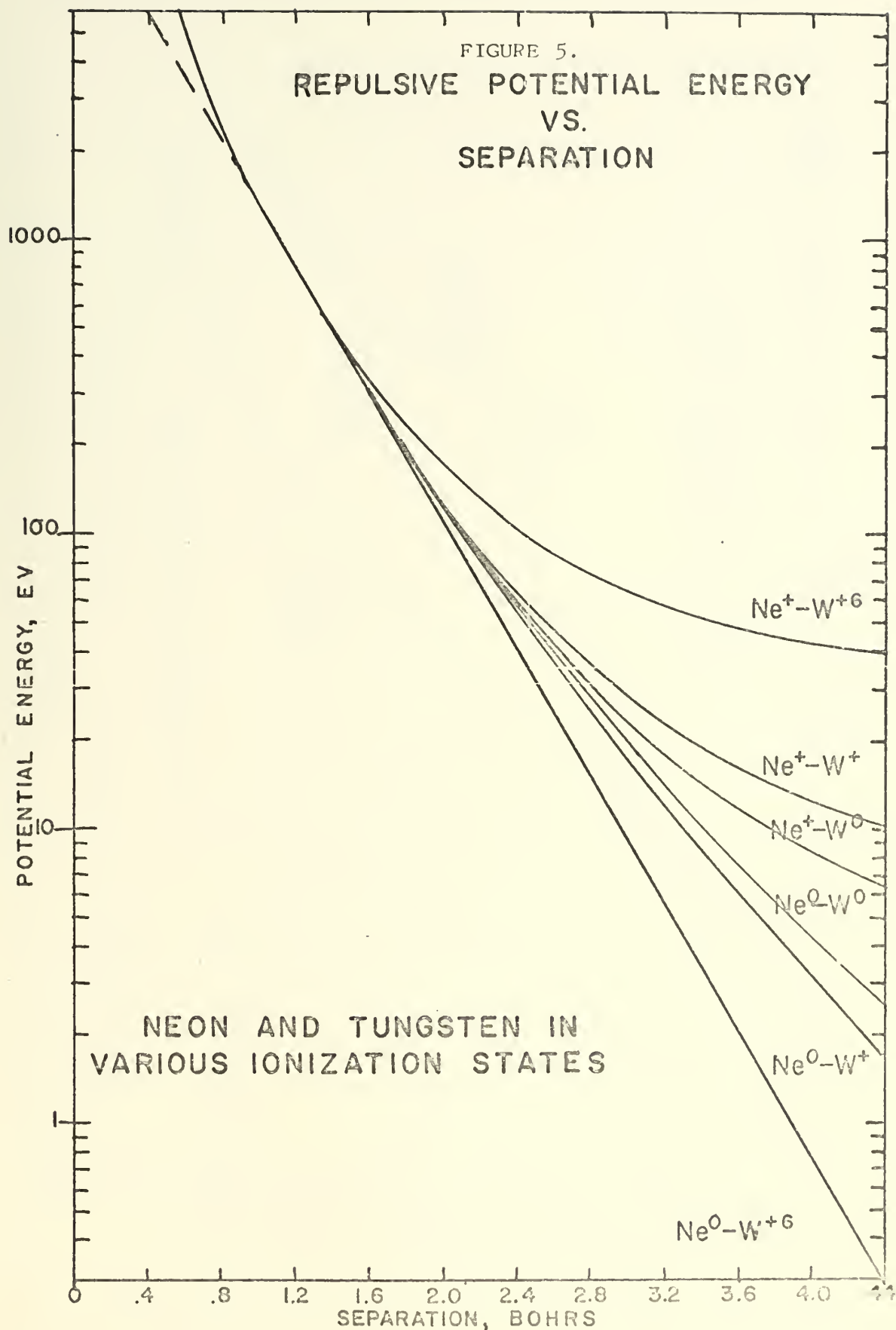




FIGURE 6.

MOTION IN -Y DIRECTION (TOWARD SURFACE)  
VS TIME

RELATIVE MOTION TOWARD SURFACE, LU

TUNGSTEN INT B  
IN LAYER 5

METHOD 2, DTI = .02, V = 1/2

METHOD 1  
DTI = .02  
V = 0

METHOD 2  
DTI = .02  
V = 0

METHOD 2  
DTI = .05  
V = 0

V = 1/2: VELOCITIES HALVED  
V = 0: VELOCITIES ZEROED

TIMESTEP NUMBER

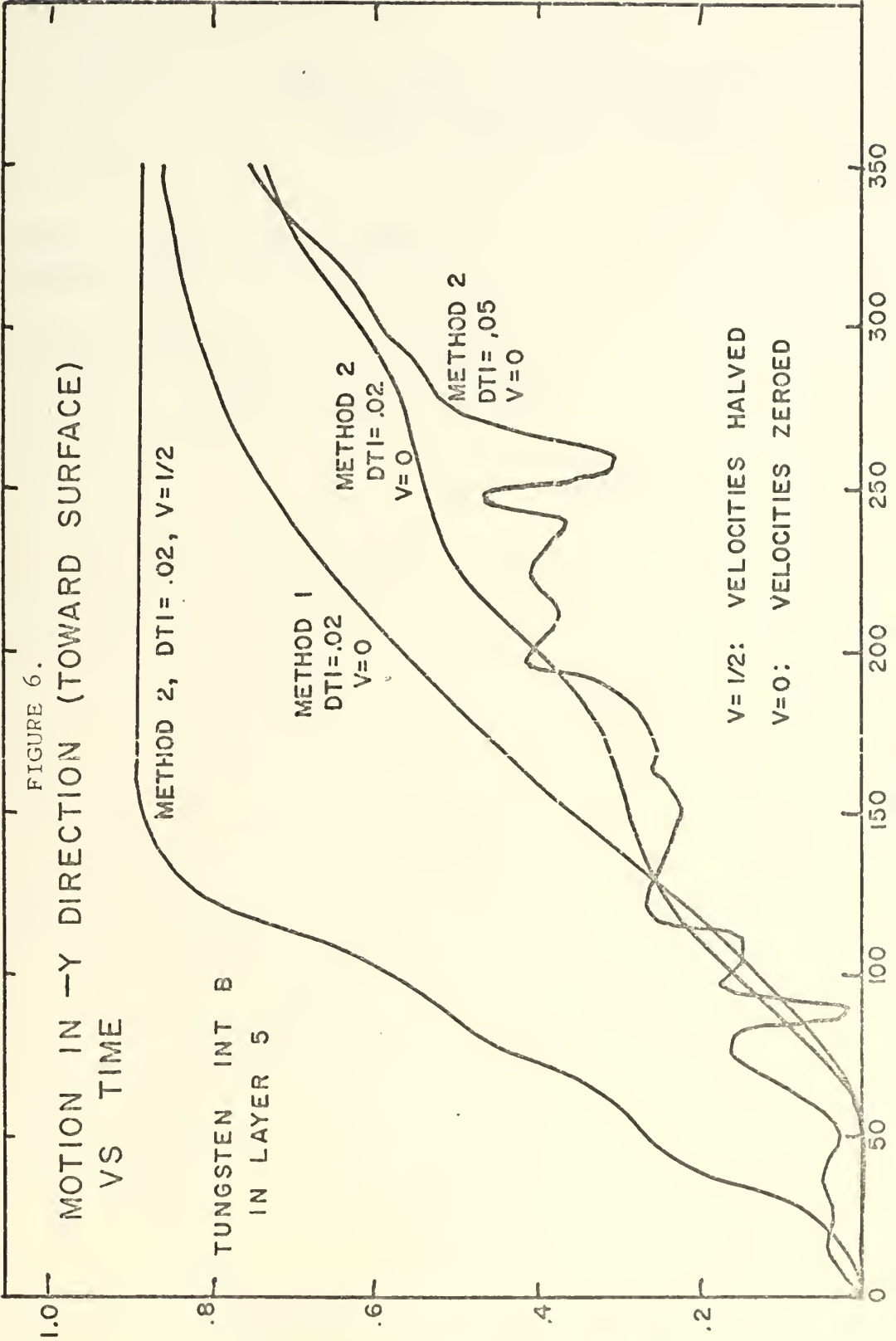


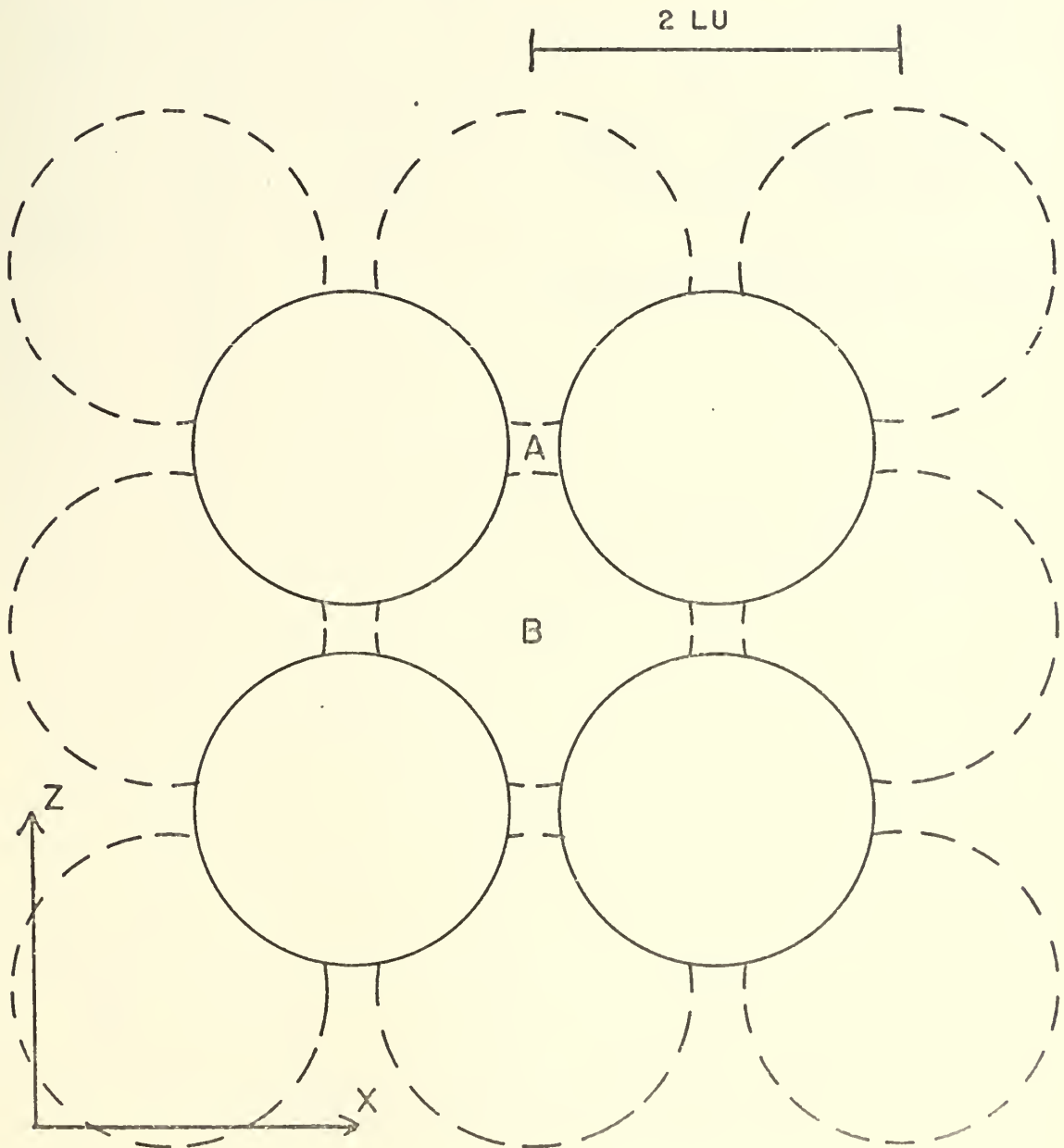


FIGURE 7.

BCC (100) ORIENTATION  
HARD SPHERE MODEL

SOLID LINE: "Y" PLANE  
DASHED LINE: "Y-1" PLANE

INTERSTITIALS IN "Y" PLANE:  
INT A IN  $\langle 010 \rangle$  OPEN CHANNEL  
INT B HIDDEN FROM SURFACE





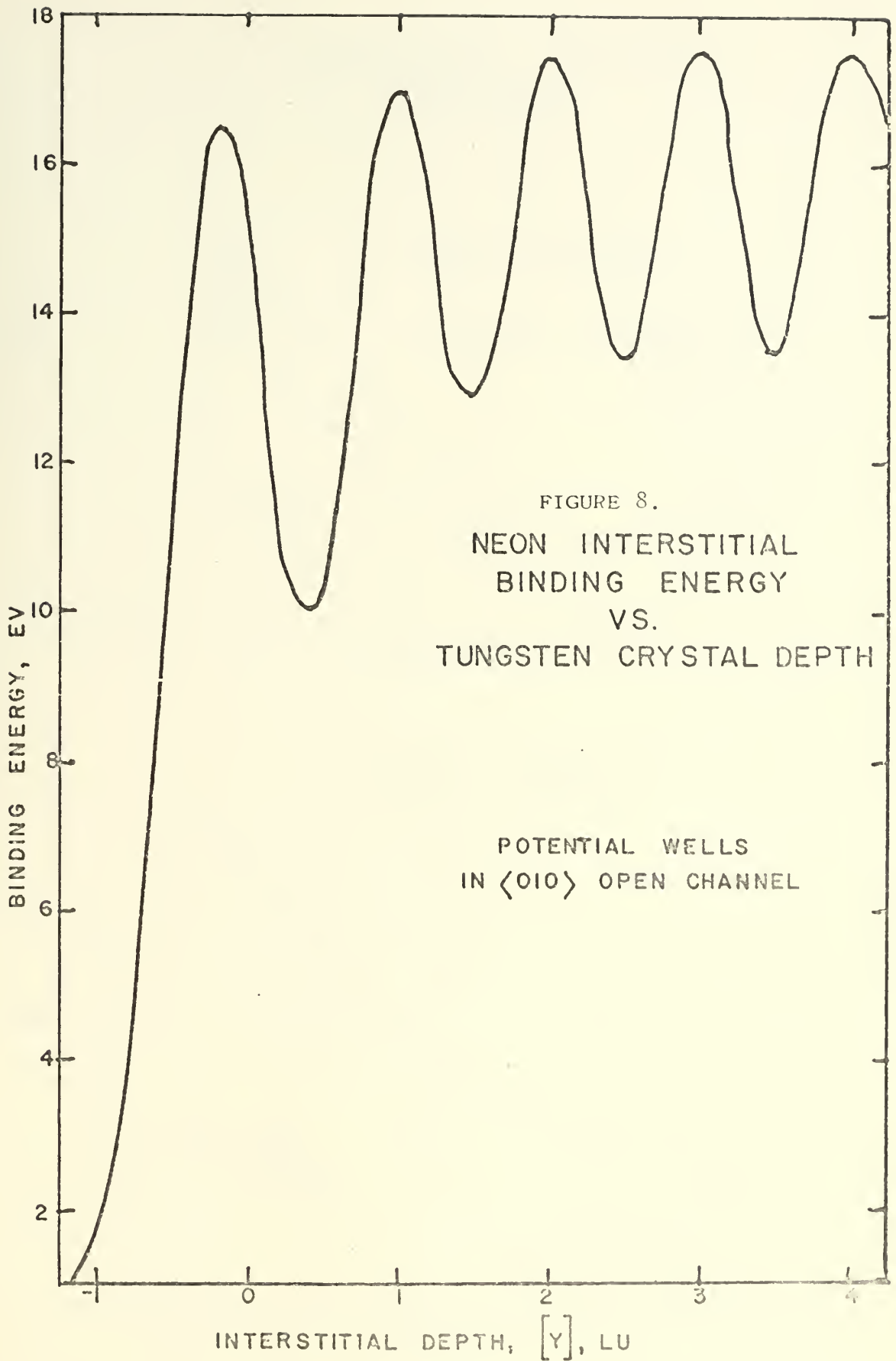
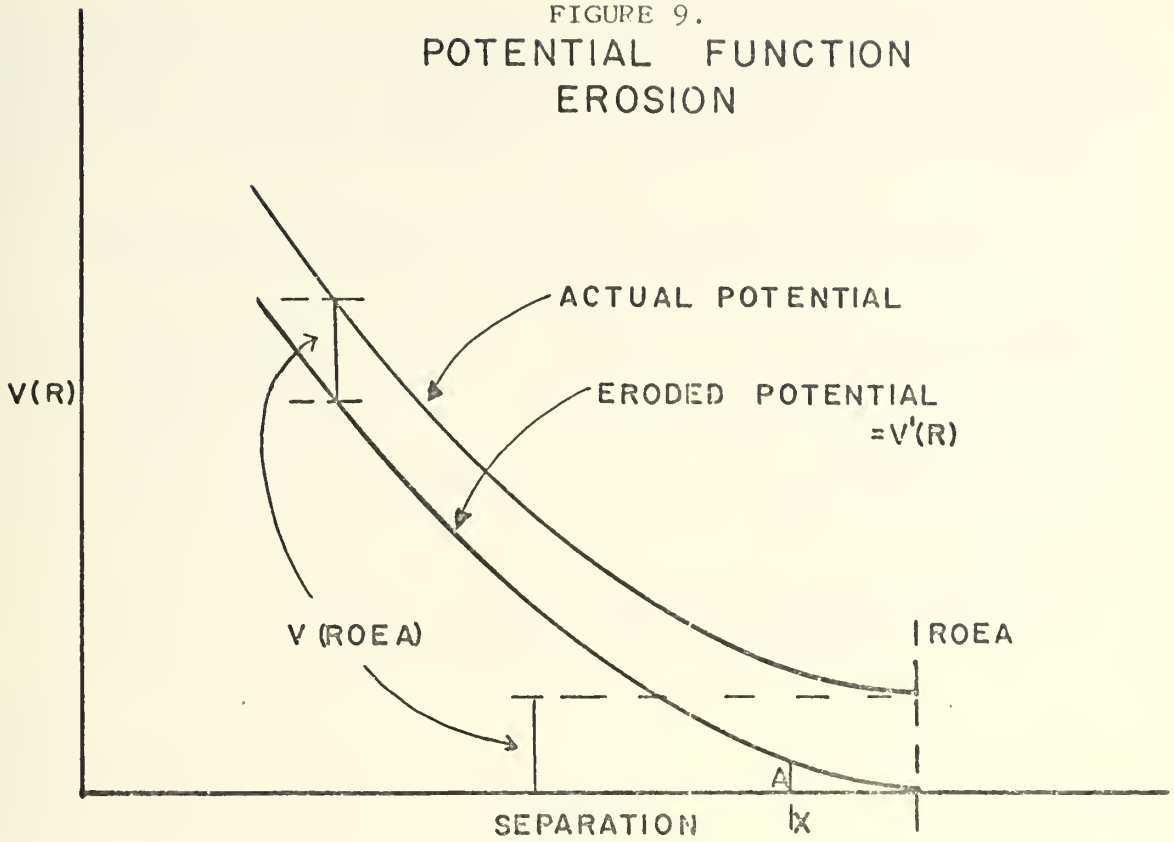


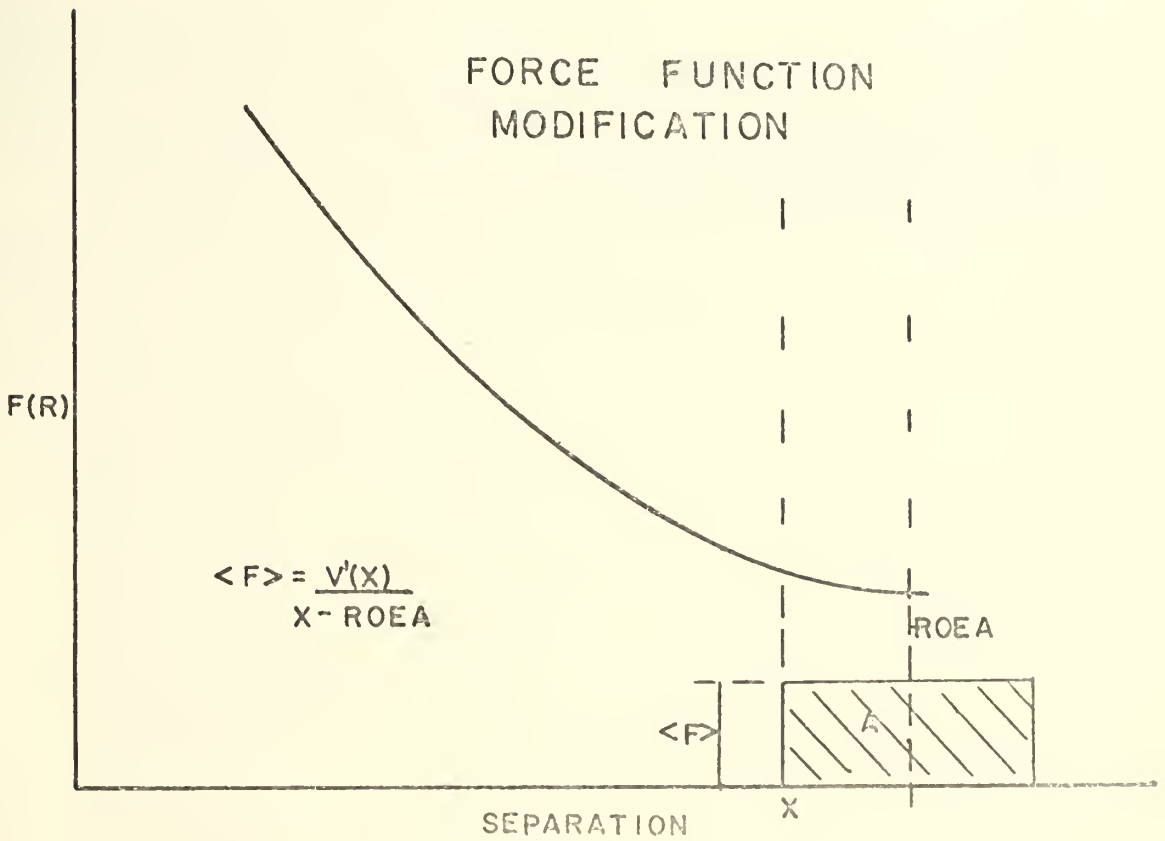




FIGURE 9.  
 POTENTIAL FUNCTION  
 EROSION



FORCE FUNCTION  
 MODIFICATION





C  
 THIS PROGRAM GENERATES VARIOUS TYPES AND ORIENTATIONS OF  
 CRYSTAL LATTICES, AND INJECTS A VACANCY, INTERSTITIAL, OR  
 REPLACEMENT IMPURITY AT A DESIRED LOCATION. IT THEN, BY USE  
 OF ATOMIC POTENTIAL PARAMETERS AND NEWTONIAN MECHANICS, CAL-  
 CULATES THE DYNAMIC RESULTS OF THE SYSTEM; OUTPUTTING POS-  
 ITION, VELOCITY, AND ENERGY VALUES FOR EACH ATOM IN THE  
 CRYSTAL.

C  
 DIMENSIONING OF VARIABLES NOT NEEDED IN COMMON  
 DIMENSION VX(1000),VY(1000),VZ(1000),PKE(1000)  
 DIMENSION DX(1000),DY(1000),DZ(1000),PTE(1000)  
 DIMENSION RXK(1000),RYK(1000),RZK(1000)

C  
 COMMON LABELING OF VARIABLES REQUIRED IN OTHER SUBROUTINES  
 COMMON/COM1/RX(1000),RY(1000),RZ(1000),LCUT(1000),  
 1LL,LD,ITYPE,NVAC  
 COMMON/COM2/IH1(20),IH2(8),IHS(10),IHB(6),IHT(6),  
 1TARGET(4),TMAS,BULLET(4),BMAS,PLANE,TEMP,THERM  
 COMMON/COM3/RXI(1000),RYI(1000),RZI(1000),CVR,EVR,  
 1NT,TIME,DT,DT1,ILAY  
 COMMON/COM4/IX,IY,IZ,SCX,SCY,SCZ,IDEEP,D1X,D1Y,D1Z  
 COMMON/COM5/ROE,ROE2,ROEM,EXA,EXB,PEXA,PEXB,FXA,PFXA,  
 1IQ,TSAVE,BSAVE  
 COMMON/COM6/FX(1000),FY(1000),FZ(1000),PAC,PFPTC,FM  
 COMMON/COM7/PPTC,TPOT,PPE(1000),TLPE,ROEL,ROEL2,NEW  
 COMMON/COM8/ROEA,ROEB,ROEC,ROEC2,CPC,CP1,CP2,CP3,  
 1CF0,CF1,CF2,CGD1,CGD2,CGB1,CGB2,CGF1,CGF2  
 COMMON/COMA/ A(4,5),MCRO

C  
 READ STATEMENT FORMATS  
 9010 FORMAT(20A4)  
 9020 FORMAT(8A4,3F8.5,2F5.2)  
 9030 FORMAT(4A4,3F8.5,6A4,F6.2)  
 9040 FORMAT(F6.2,F5.3,I5,6I4,3F5.2,I2)  
 9050 FORMAT(10A4,A4,4I3,F8.4,I4)

C  
 WRITE STATEMENT FORMATS  
 9610 FORMAT(1H1)  
 9620 FORMAT(47X,'SUMMARY OF ATOMS'///,35X,8A4,', NT =',I4,///,  
 13(' ATOM POSITION BIND ENERGY '),//)  
 9630 FORMAT(3(I5,3F6.2,F8.4,8X))  
 9640 FORMAT(/4X,F10.3,25H EV,TOTAL KINETIC ENERGY,,F10.3,  
 127H EV,TOTAL POTENTIAL ENERGY,F10.3,13H EV,REDUCTION,  
 1//,20X,F10.3,50HEV, LOCAL POTENTIAL ENERGY, IN VOLUME  
 1OF RADIUS = ,F5.2, /30X, 16HCHANGE IN TLPE =, F10.3)  
 9650 FORMAT(105X,4HPAGE,I3,/,1H1)  
 9660 FORMAT(/ ' ATOM DX DY PE DZ TE'//)  
 1VX VY VZ KE  
 9670 FORMAT(1I8,3F10.3,3F10.1,3F10.4 )

C  
 INITIALIZING  
 START=C.01\*ITIME(XX)  
 DO 2 I=1,1000  
 LCUT(I)=C  
 RXK(I)=0.0  
 RYK(I)=0.0  
 RZK(I)=0.0  
 VX(I)=0.0  
 VY(I)=0.0  
 VZ(I)=0.0  
 PKE(I)=0.0  
 PPE(I)=0.0  
 PTE(I)=0.0  
 RX(I)=0.0  
 RY(I)=0.0  
 RZ(I)=0.0  
 FX(I)=0.0  
 FY(I)=0.0  
 FZ(I)=0.0  
 RXI(I)=0.0  
 RYI(I)=0.0



```
2 RZI(I)=0.0
  ISHUT=1
  NRUN=0
```

```
C
INPUT DATA
  READ ( 5,9010 ) IH1
  READ ( 5,9020 ) IH2,DCON,ALPHA,RE,ROEC,ROEL
  READ ( 5,9030 ) BULLET,BMAS,PEXA,PEXB,IHB,THERM
  READ ( 5,9030 ) TARGET,TMAS,EXA,EXB,IHT,TEMP
  READ ( 5,9040 ) EVR,DTI,NTT,NS,ND,IP,IDEEP,ITYPE,NVAC,
1D1X,D1Y,D1Z,IQ
  READ ( 5,9050 ) IHS,PLANE,LS,IX,IY,IZ,CVR,MCRO
```

```
C
CONSTANTS AND SCALING FACTORS
```

```
ROE2=3.0
ROE=SQRT(ROE2)
ROEM = ROE-DTI
ROEL2=ROEL*ROEL
CVE=1.60E-19
EV=EVR*1.0E+3
CVM=1.672E-27
FM=1.0E-10
FM2=FM*FM
CVD=CVR*1.0E-10
CVED=CVE/CVD
PTMAS=TMAS*CVM
PBMAS=BMAS*CVM
HTMAS=0.5*PTMAS/CVE
HBMAS=0.5*PBMAS/CVE
TSAVE=BMAS/(BMAS+TMAS)
BSAVE=TMAS/(BMAS+TMAS)
```

```
C
REPULSIVE POTENTIAL PARAMETERS
```

```
FXA=ALOG(-EXB*CVED)+EXA
PFXA=ALOG(-PEXB*CVED)+PEXA
PPTC=EXP(PEXA+PEXB*ROE)
PAC=ALOG(CVED)+PEXA
PFPTC=EXP(PAC+PEXB*ROE)
```

```
C
ATTRACTIVE POTENTIAL PARAMETERS
```

```
CGD1=ALOG(DCON)+2.0*ALPHA*RE
CGD2=ALOG(2.0*DCON)+ALPHA*RE
CGB1=-2.0*ALPHA*CVR
CGB2=-ALPHA*CVR
CGF1=ALOG(-CGB1*CVED)+CGD1
CGF2=ALOG(-CGB2*CVED)+CGD2
```

```
C
CUTOFF DISTANCES FOR ATTRACTIVE AND REPULSIVE POTENTIALS
```

```
ROEA=1.50/CVR
ROEB=2.0/CVR
ROEC2=ROEC*ROEC
```

```
C
PARAMETERS FOR CALCULATION OF THE BEST CUBIC FIT IN THE GAP
BETWEEN MAXIMUM DISTANCE CUTOFF OF THE REPULSIVE POTENTIAL
(ROEA), AND MINIMUM DISTANCE CUTOFF OF THE ATTRACTIVE POTEN-
TIAL (ROEB). SUBROUTINE CROSYM ACTUALLY PERFORMS THIS CURVE
FITTING.
```

```
A(1,1)=1.0
A(1,2)=ROEA
A(1,3)=ROEA*ROEA
A(1,4)=ROEA**3
A(1,5)=EXP(EXA+EXB*ROEA)
A(2,1)=1.0
A(2,2)=ROEB
A(2,3)=ROEB*ROEB
A(2,4)=ROEB**3
A(2,5)=EXP(CGD1+CGB1*ROEB)-EXP(CGD2+CGB2*ROEB)
A(3,1)=0.0
A(3,2)=-1.0
A(3,3)=-2.0*ROEA
A(3,4)=-3.0*ROEA*ROEA
A(3,5)=EXP(FXA+EXB*ROEA)/CVED
```



```

A(4,1)=0.0
A(4,2)=-1.0
A(4,3)=-2.0*ROEB
A(4,4)=-3.0*ROEB*ROEB
A(4,5)=(EXP(CGF1+CGB1*ROEB)-EXP(CGF2+CGB2*ROEB))/CVED
CALL CROSYM
CPO=A(1,5)
CP1=A(2,5)
CP2=A(3,5)
CP3=A(4,5)
CFO=-CP1*CVED
CF1=-2.0*CP2*CVED
CF2=-3.0*CP3*CVED

```

C

SELECTION OF THE DESIRED CRYSTAL STRUCTURE AND ORIENTATION. 100, 110, AND 111 PLANES OF FACE-CENTERED, BODY-CENTERED, AND DIAMOND STRUCTURES ARE ALLOWED. ILAY AND IDEEP ARE VARIABLES ESTABLISHING THE NUMBER OF MOBILE LAYERS IN THE CRYSTAL. PXI(I) AND RXK(I) ARE VARIABLES SAVING THE ORIGINAL X-POSITION OF THE I'TH ATOM. Y AND Z POSITIONS ARE ANALOGOUS.

```

GO TO ( 11,12,13,14,15,16,17,18,19),LS
11 CALL L100
GO TO 30
12 CALL L110
GO TO 30
13 CALL L111
GO TO 30
14 CALL B100
GO TO 30
15 CALL B110
GO TO 30
16 CALL B111
GO TO 30
17 CALL D100
GO TO 30
18 CALL D110
GO TO 30
19 CALL D111
30 ILAY=IDEEP
IF(IDEEP) 35,35,40
35 LO=LL
ILAY=IY
40 DO 45 I=1,LL
RXK(I)=RX(I)
RYK(I)=RY(I)
RZK(I)=RZ(I)
RXI(I)=RX(I)
RYI(I)=RY(I)
45 RZI(I)=RZ(I)

```

C

THIS SECTION ALLOWS ONE TO REPEAT A RUN OF THE PROGRAM WITH DIFFERENT DATA WITHOUT REPEATING INITIALIZATION, POTENTIAL PARAMETER CALCULATIONS AND CRYSTAL LATTICE BUILDING. SUBROUTINE PLACE USES LCUT(I) AND NVAC TO CREATE VACANCIES, INTERSTITIALS, AND REPLACEMENT IMPURITIES AT DESIRED LOCATIONS IN THE LATTICE.

```

IF(NRUN.EQ.0) GO TO 60
50 READ ( 5,9040) EVR,DTI,NTT,NS,ND,IP,IDEEP,ITYPE,NVAC,
1D1X,D1Y,D1Z,IQ
IF(DTI.EQ.0) GO TO 9999
DO 55 I=1,LL
LCUT(I)=0
RX(I)=RXI(I)
RY(I)=RYI(I)
RZ(I)=RZI(I)
RXK(I)=RXI(I)
RYK(I)=RYI(I)
55 RZK(I)=RZI(I)
60 NRUN=1
CALL PLACE
RXI(1)=RX(1)

```





```

RYI(1)=RY(1)
RZI(1)=RZ(1)
RXK(1)=RX(1)
RYK(1)=RY(1)
RZK(1)=RZ(1)
DO 65 I=1,LL
VX(I)=C.0
VY(I)=C.0
VZ(I)=C.0
PPE(I)=0.0
PKE(I)=C.0
65 PTE(I)=0.0
TPOT=C.0
NEW=C

```

C  
THE ENERGY SUBROUTINE CALCULATES THE POTENTIAL ENERGY OF EACH ATOM IN THE LATTICE. SUBROUTINE LOCAL SUMS UP THIS ENERGY FOR ALL ATOMS WITHIN A SPECIFIC RADIUS OF THE POINT DEFECT.

```

CALL ENERGY
CALL LOCAL
BIND=-TPOT
TPKE=0.0
TLPEO=TLPE
DLPE=TLPE-TLPEO
TE=TPOT+BIND

```

C  
THIS SECTION PRINTS OUT X, Y, AND Z COORDINATES, IN LATTICE UNITS, AND BINDING ENERGIES OF EACH ATOM IN THE CRYSTAL AT TIME ZERO.

```

TIME=C.0
NT=0
WRITE ( 6,9610)
WRITE ( 6,9620) IH2,NT
DO 70 I=1,LL,3
K=I+1
J=I+2
70 WRITE ( 6,9630) I,RX(I),RY(I),RZ(I),PPE(I),K,RX(K),
1RY(K),RZ(K),PPE(K),J,RX(J),RY(J),RZ(J),PPE(J)
WRITE ( 6,9640) TPKE,TPOT,TE,TLPE,ROEL,DLPE
NPAGE=1
NPAGE=NPAGE+1
WRITE ( 6,9650) NPAGE

```

C  
THIS IS THE MAIN BODY OF THE PROGRAM. BY USE OF THE AVERAGE FORCE METHOD, EXPLAINED IN DETAIL IN APPENDIX C, IT DOES ALL THE DYNAMICS FOR EACH INDIVIDUAL ATOM. SUBROUTINE STEP CALCULATES ALL MUTUAL FORCES AMONG THE ATOMS. BASED ON THE FORCES, THIS SECTION THEN CALCULATES TEMPORARY POSITIONS FOR THE PRIMARY, AND ALL OTHER ATOMS; RECALCULATES FORCES IN STEP; AND THEN RECALCULATES FINAL POSITIONS FOR THE PRIMARY AND ALL OTHER ATOMS, BASED ON THE AVERAGE OF THESE TWO FORCES. THIS SECTION ALSO INCLUDES ALL KINETIC ENERGY CALCULATIONS, BASED ON THE VELOCITIES INVOLVED; AND FINALLY CALCULATES A NEW TIMESTEP DURATION FOR USE IN THE NEXT TIME-STEP, BASED ON EITHER A MAXIMUM ALLOWED FORCE, OR MAXIMUM ALLOWED ENERGY. (SEE APP. C) VELOCITIES ARE HALVED AT THE END OF EACH TIMESTEP AS A METHOD OF DAMPING.

```

95 TFAC=2.0*PTMAS*DTI*CVD
TFACB=2.0*PBMAS*DTI*CVD
DT=1.0E-14
100 DTOD=DT/CVD
HDTOD=C.5*DTOD
DTOM=DT/PTMAS
HDTOM=C.5*DTOM
DTOMB=DT/PBMAS
HDTOMB=C.5*DTOMB
200 CALL STEP
IF(LCUT(1).GT.C) GO TO 240
I=1
RXK(I)=RX(I)
RYK(I)=RY(I)

```



```

RZK(I)=RZ(I)
RX(I)=RX(I)+DTOD*(HDTOMB*FX(I)+VX(I))
RY(I)=RY(I)+DTOD*(HDTOMB*FY(I)+VY(I))
RZ(I)=RZ(I)+DTOD*(HDTOMB*FZ(I)+VZ(I))
240 DO 245 I=2,LD
IF(LCUT(I).GT.0)GO TO 245
RXK(I)=RX(I)
RYK(I)=RY(I)
RZK(I)=RZ(I)
RX(I)=RX(I)+DTOD*(HDTOM*FX(I)+VX(I))
RY(I)=RY(I)+DTOD*(HDTOM*FY(I)+VY(I))
RZ(I)=RZ(I)+DTOD*(HDTOM*FZ(I)+VZ(I))
245 CONTINUE
CALL STEP
EMAX=0.0
FMAX=0.0
TIME=TIME+DT
NT=NT+1
IF(LCUT(1).GT.0) GO TO 265
I=1
VSS=VX(I)
VX(I)=VSS+HDTOMB*FX(I)
RX(I)=RXK(I)+(VX(I)+VSS)*HDTOD
VSS=VY(I)
VY(I)=VSS+HDTOMB*FY(I)
RY(I)=RYK(I)+(VY(I)+VSS)*HDTOD
VSS=VZ(I)
VZ(I)=VSS+HDTOMB*FZ(I)
RZ(I)=RZK(I)+(VZ(I)+VSS)*HDTOD
PKE(I)=VX(I)*VX(I)+VY(I)*VY(I)+VZ(I)*VZ(I)
EMAX=PKE(I)
FMAX=FX(I)*FX(I)+FY(I)*FY(I)+FZ(I)*FZ(I)
FORC1=FMAX
260 FX(I)=0.0
FY(I)=0.0
FZ(I)=0.0
265 DO 280 I=2,LD
IF(LCUT(I).GT.0)GO TO 280
VSS=VX(I)
VX(I)=VSS+HDTOM*FX(I)
RX(I)=RXK(I)+(VX(I)+VSS)*HDTOD
VSS=VY(I)
VY(I)=VSS+HDTOM*FY(I)
RY(I)=RYK(I)+(VY(I)+VSS)*HDTOD
VSS=VZ(I)
VZ(I)=VSS+HDTOM*FZ(I)
RZ(I)=RZK(I)+(VZ(I)+VSS)*HDTOD
PKE(I)=VX(I)*VX(I)+VY(I)*VY(I)+VZ(I)*VZ(I)
275 F2=FX(I)*FX(I)+FY(I)*FY(I)+FZ(I)*FZ(I)
FX(I)=0.0
FY(I)=0.0
FZ(I)=0.0
IF(F2.GT.FMAX) FMAX=F2
IF(PKE(I).GT.EMAX) EMAX=PKE(I)
280 CONTINUE
IF(EMAX.EQ.0.0) GO TO 285
IF(FMAX.EQ.0.0) GO TO 285
GO TO 287
285 DT=1.0E-14
GO TO 300
287 IF(EMAX.EQ.PKE(1)) GO TO 290
IF(FMAX.EQ.FORC1) GO TO 290
EMAX=SQRT(EMAX)
FMAX=SQRT(FMAX)
DT=SQRT(TFAC/FMAX)
FTERM=FMAX*DT/(2.0*PTMAS)
GO TO 295
290 EMAX=SQRT(PKE(1))
FMAX=SQRT(FORC1)
IF(FORC1.EQ.0.0) GO TO 285
DT=SQRT(TFACB/FMAX)
FTERM=FMAX*DT/(2.0*PBMAS)

```



```

295 IF(EMAX.LE.FTERM) GO TO 300
    FDTI=DTI#CVD
    DT=FDTI/EMAX
300 IF(ISHUT.EQ.-1) GO TO 400
310 IF(NS-NT) 400,400,320
320 DO 325 I=1,LL
    VX(I)=0.5#VX(I)
    VY(I)=0.5#VY(I)
325 VZ(I)=0.5#VZ(I)
    GO TO 100
340 DO 350 I=1,LL
    RX(I)=RXK(I)
    RY(I)=RYK(I)
350 RZ(I)=RZK(I)
    NTT=NT

```

C  
THE PRINT SUBROUTINE PLACES A HEADING OF PERTINENT INFORMATION AT THE TOP OF EACH TIMESTEP PRINTOUT.  
400 CALL PRINT

C  
POTENTIAL ENERGY AND LOCAL POTENTIAL ENERGY FOR EACH ATOM ARE CALCULATED BASED ON THE NEW POSITIONS. SUMMATIONS OF TOTAL POTENTIAL AND KINETIC ENERGY FOR THE LATTICE ARE PERFORMED. DX, DY, AND DZ KEEP TRACK OF MOTION RELATIVE TO THE INITIAL POSITION AT TIME ZERO FOR EACH ATOM.

```

410 TPOT=0.0
    DO 450 I=1,LL
        PPE(I)=0.0
450 PTE(I)=0.0
    CALL ENERGY
    CALL LOCAL
    DLPE=TLPE-TLPE0
    PKE(1)=HBMAS#PKE(1)
    TPKE=PKE(1)
    PTE(1)=PKE(1)+PPE(1)
    DO 620 I=2,LL
        PKE(I)=HTMAS#PKF(I)
        TPKE=TPKE+PKE(I)
620 PTE(I)=PKE(I)+PPE(I)
    TE=TPOT+BIND
    WRITE ( 6,9660)
700 DO 750 I=1,LD
    DX(I)=RX(I)-RXI(I)
    DY(I)=RY(I)-RYI(I)
    DZ(I)=RZ(I)-RZI(I)

```

C  
THIS SECTION PRINTS THE RELATIVE MOTION, VELOCITY, AND ENERGY OF EACH ATOM, FOR EVERY TIMESTEP SO DESIGNATED: IE, EVERY ND' TH TIMESTEP, BEGINNING WITH #NS AND ENDING WITH #NTT.

```

720 WRITE ( 6,9670) I,DX(I),DY(I),DZ(I),VX(I),VY(I),
    1VZ(I),PKE(I),PPE(I),PTE(I)
750 CONTINUE
    WRITE ( 6,9640) TPKE,TPOT,TE,TLPE,ROEL,DLPE
    WRITE ( 6,9650) NPAGE
    NPAGE=NPAGE+1
    IF(NT-NTT) 760,950,950
760 DO 780 I=1,LL
    VX(I)=0.5#VX(I)
    VY(I)=0.5#VY(I)
    VZ(I)=0.5#VZ(I)
780 CONTINUE
790 NS=NS+ND
    GO TO 100
950 CONTINUE

```

C  
THIS SECTION PRINTS OUT X, Y, AND Z COORDINATES AND BINDING ENERGIES OF EACH ATOM IN THE CRYSTAL AT THE END OF THE PROGRAM.

```

955 WRITE ( 6,9620) IH2,NT
    DO 965 I=1,LL,3
        K=I+1

```



```

      J=I+2
965  WRITE ( 6,9630) I,RX(I),RY(I),RZ(I),PPE(I),K,RX(K),
      1RY(K),RZ(K),PPE(K),J,RX(J),RY(J),RZ(J),PPE(J)
      WRITE ( 6,9640) TPKE,TPOT,TE,TLPE,ROEL,DLPE
      WRITE ( 6,9650) NPAGE
1000 IF(ISHUT) 9999,50,50
9999 STOP
      END

```

### SUBROUTINE CROSYM

C SOLVES M SIMULTANEOUS EQUATIONS BY THE METHOD OF CROUT  
 THIS SUBROUTINE FITS THE BEST CUBIC BETWEEN THE REPULSIVE  
 AND ATTRACTIVE PARTS OF THE POTENTIAL.

```

C
COMMON/COMA/ A(4,5),MCRO
M=MCRO
N=M+1
I1=1
100  I3=I1
      SUM=ABS(A(I1,I1))
      DO 120 I=I1,M
      IF(SUM-ABS(A(I,I1))) 110,120,120
110  I3=I
      SUM=ABS(A(I,I1))
120  CONTINUE
      IF(I3-I1) 130,150,130
130  DO 140 J=1,N
      SUM=-A(I1,J)
      A(I1,J)=A(I3,J)
140  A(I3,J)=SUM
150  I3=I1+1
      DO 160 I=I3,M
160  A(I,I1)=A(I,I1)/A(I1,I1)
170  J2=I1-1
      I3=I1+1
      IF(J2) 180,200,180
180  DO 190 J=I3,N
      DO 190 I=1,J2
190  A(I1,J)=A(I1,J)-A(I1,I)*A(I,J)
      IF(I1-M) 200,220,200
200  J2=I1
      I1=I1+1
      DO 210 I=I1,M
      DO 210 J=1,J2
210  A(I,I1)=A(I,I1)-A(I,J)*A(J,I1)
      IF(I1-M) 100,170,100
220  DO 240 I=1,M
      J2=M-I
      I3=J2+1
      A(I3,N)=A(I3,N)/A(I3,I3)
      IF(J2) 230,250,230
230  DO 240 J=1,J2
240  A(J,N)=A(J,N)-A(I3,N)*A(J,I3)
250  RETURN
      END

```

### SUBROUTINE L100

C THIS IS A LATTICE GENERATOR FOR THE FCC (100) ORIENTATION.  
 THE CRYSTAL IS DEVELOPED IN THE ORDER, Z FOLLOWED BY Y,  
 FOLLOWED BY X.  
 IT CONTAINS A NONSTANDARD USE OF THE SURFACE RELAXATION  
 PARAMETER.

```

C
COMMON/COM1/RX(1000),RY(1000),RZ(1000),LCUT(1000),
1LL,LD,ITYPE,NVAC
COMMON/COM4/IX,IY,IZ,SCX,SCY,SCZ,IDEEP,D1X,D1Y,D1Z
DIMENSION YLAX(20)
DATA YLAX/20*0.0/

```





```

YLAX(1)=-0.097
YLAX(2)=-0.024
SCX=1.0
SCY=1.0
SCZ=1.0
M=2
JT=0
Y=-SCY
DO 60 J=1,IY
Y=Y+SCY
KT=0
Z=-SCZ
DO 59 K=1,IZ
Z=Z+SCZ
IT=0
X=-SCX
DO 58 I=1,IX
X=X+SCX
ITT=IT+JT+KT
IF(ITT-(ITT/2)*2) 57,30,57
30 RX(M)=X
RY(M)=Y+YLAX(J)
RZ(M)=Z
M=M+1
57 CONTINUE
IT =IT+1
58 CONTINUE
KT=KT+1
59 CONTINUE
JT = JT + 1
IF(IDEEP-JT) 60,110,60
60 CONTINUE
LL=M-1
100 RETURN
110 LD=M-1
GO TO 60
END

```

SUBROUTINE L110

C  
THIS IS A LATTICE GENERATOR FOR THE FCC (110) ORIENTATION.  
THE CRYSTAL IS DEVELOPED IN THE ORDER, Z FOLLOWED BY Y,  
FOLLOWED BY X.  
IT CONTAINS A NONSTANDARD USE OF THE SURFACE RELAXATION  
PARAMETER.  
C

```

COMMON/COM1/RX(1000),RY(1000),RZ(1000),LCUT(1000),
1LL,LD,ITYPE,NVAC
COMMON/COM4/IX,IY,IZ,SCX,SCY,SCZ,IDEEP,D1X,D1Y,D1Z
DIMENSION YLAX(20)
DATA YLAX/20*0.0/
YLAX(1)=-0.07
YLAX(2)=-0.02
RO=1.0/SQRT(2.0)
SCX=RO
SCY=RO
SCZ=1.0
M=2
JT=0
Y=-SCY
DO 60 J=1,IY
Y=Y+SCY
KT=0
Z=-SCZ
DO 59 K=1,IZ
Z=Z+SCZ
IT=0
X=-SCX
DO 58 I=1,IX
X=X+SCX
IF(IT-(IT/2)*2) 21,11,21

```



```

11 IF(JT-(JT/2)*2) 57,12,57
12 IF(KT-(KT/2)*2) 57,30,57
21 IF(JT-(JT/2)*2) 22,57,22
22 IF(KT-(KT/2)*2) 30,57,30
30 RX(M)=X
   RY(M)=Y+YLAX(J)
   RZ(M)=Z
   M=M+1
57 CONTINUE
   IT =IT+1
58 CONTINUE
   KT=KT+1
59 CONTINUE
   JT = JT + 1
   IF(IDEEP-JT) 60,110,60
60 CONTINUE
   LL=M-1
100 RETURN
110 LD=M-1
   GO TO 60
   END

```

SUBROUTINE L111

C  
THIS IS A LATTICE GENERATOR FOR THE FCC (111) ORIENTATION.  
THE CRYSTAL IS DEVELOPED IN THE ORDER, Z FOLLOWED BY Y,  
FOLLOWED BY X.  
IT CONTAINS A NONSTANDARD USE OF THE SURFACE RELAXATION  
PARAMETER.  
C

```

COMMON/CCM1/RX(1000),RY(1000),RZ(1000),LCUT(1000),
1 LL,LD,ITYPE,NVAC
COMMON/COM4/IX,IY,IZ,SCX,SCY,SCZ,IDEEP,D1X,D1Y,D1Z
DIMENSION YLAX(20)
DATA YLAX/20*0.0/
YLAX(1)=-0.04
YLAX(2)=-0.01
SCX=1.0/SQRT(2.0)
SCY=2.0/SQRT(3.0)
SCZ=SQRT(1.5)
SSCZ=SCZ/3.0
M=2
JT=0
Y=-SCY
DO 60 J=1,IY
Y=Y+SCY
JTS=JT+JT/3
Z=-SCZ
KT=0
DO 59 K=1,IZ
Z=Z+SCZ
IT=0
X=-SCX
DO 58 I=1,IX
X=X+SCX
IN=IT+JTS+KT
IF(IN-(IN/2)*2) 57,30,57
30 RX(M)=X
   RY(M)=Y+YLAX(J)
   IF(JT-3*(JT/3)) 41,45,41
41 JTT=JT
42 JTT=JTT-3
   IF(JTT) 43,45,42
43 JTT=JTT+3
   ZP=JTT
   RZ(M)=Z+ZP*SSCZ
   GO TO 50
45 RZ(M)=Z
50 M=M+1
57 CONTINUE
   IT=IT+1

```



```

58 CONTINUE
   KT=KT+1
59 CONTINUE
   JT=JT+1
   IF(IDEEP-JT) 60,110,60
60 CONTINUE
   LL=M-1
100 RETURN
110 LD=M-1
   GO TO 60
   END

```

SUBROUTINE B100

C THIS IS A LATTICE GENERATOR THE THE BCC (100) ORIENTATION.  
 THE CRYSTAL IS DEVELOPED IN THE ORDER, X FOLLOWED BY Z,  
 FOLLOWED BY Y.  
 IT CONTAINS A NONSTANDARD USE OF THE SURFACE RELAXATION  
 PARAMETER.

```

C
COMMON/COM1/RX(1000),RY(1000),RZ(1000),LCUT(1000),
1LL,LD,ITYPE,NVAC
COMMON/COM4/IX,IY,IZ,SCX,SCY,SCZ,IDEEP,D1X,D1Y,D1Z
DIMENSION YLAX(20)
DATA YLAX/20*0.0/
YLAX(1)=-0.20
YLAX(2)=-0.03
SCX=1.0
SCY=1.0
SCZ=1.0
M = 2
JT=0
Y=-SCY
DO 60 J=1,IY
Y=Y+SCY
KT=0
Z=-SCZ
DO 59 K=1,IZ
Z=Z+SCZ
IT=0
X=-SCX
DO 58 I=1,IX
X=X+SCX
11 IF(IT-(IT/2)*2) 21,11,21
12 IF(JT-(JT/2)*2) 57,12,57
21 IF(KT-(KT/2)*2) 57,30,57
22 IF(JT-(JT/2)*2) 22,57,22
22 IF(KT-(KT/2)*2) 30,57,30
30 RX(M)=X
   RY(M)=Y+YLAX(J)
   RZ(M)=Z
   M=M+1
57 IT=IT+1
58 CONTINUE
   KT=KT+1
59 CONTINUE
   JT = JT + 1
   IF(IDEEP-JT) 60,110,60
60 CONTINUE
   LL=M-1
100 RETURN
110 LD=M-1
   GO TO 60
   END

```



SUBROUTINE B110

C THIS IS A LATTICE GENERATOR THE THE BCC (110) ORIENTATION.  
 THE CRYSTAL IS DEVELOPED IN THE ORDER, X FOLLOWED BY Z,  
 FOLLOWED BY Y.  
 IT CONTAINS A NONSTANDARD USE OF THE SURFACE RELAXATION  
 PARAMETER.

```

C
COMMON/CCM1/RX(1000),RY(1000),RZ(1000),LCUT(1000),
1LL,LD,ITYPE,NVAC
COMMON/COM4/IX,IY,IZ,SCX,SCY,SCZ,IDEEP,D1X,D1Y,D1Z
DIMENSION YLAX(20)
DATA YLAX/20*C.0/
YLAX(1)=-0.10
YLAX(2)=-0.01
SCX = SQRT(2.0)
SCY = SQRT(2.0)
SCZ=1.0
M=2
JT=0
Y=-SCY
DO 60 J=1,IY
Y=Y+SCY
KT=0
Z=-SCZ
DO 59 K=1,IZ
Z=Z+SCZ
IT=0
X=-SCX
DO 58 I=1,IX
X=X+SCX
ITT=IT+JT+KT
IF (ITT-(ITT/2)*2) 57,30,57
30 RX(M)=X
PY(M)=Y+YLAX(J)
RZ(M)=Z
M = M+1
57 CONTINUE
IT = IT+1
58 CONTINUE
KT=KT+1
59 CONTINUE
JT = JT + 1
IF(IDEEP-JT) 60,110,60
60 CONTINUE
LL=M-1
RETURN
110 LD = M-1
GO TO 60
END
  
```

SUBROUTINE B111

C THIS IS A LATTICE GENERATOR FOR THE BCC (111) ORIENTATION.  
 THE CRYSTAL IS DEVELOPED IN THE ORDER, X FOLLOWED BY Z,  
 FOLLOWED BY Y.  
 IT CONTAINS A NONSTANDARD USE OF THE SURFACE RELAXATION  
 PARAMETER.

```

C
COMMON/CCM1/RX(1000),RY(1000),RZ(1000),LCUT(1000),
1LL,LD,ITYPE,NVAC
COMMON/COM4/IX,IY,IZ,SCX,SCY,SCZ,IDEEP,D1X,D1Y,D1Z
DIMENSION YLAX(20)
DATA YLAX/20*0.0/
YLAX(1)=-0.10
YLAX(2)=-0.01
SCX = SQRT(2.0)
  
```





```

SCY = SQRT(1.0/3.0)
SCZ = SQRT(6.0)
M = 2
JT=0
Y=-SCY
DO 60 J=1,IY
Y=Y+SCY
KT = 0
JJ = J-(JT/3)*3
GO TO (5,10,15),JJ
5 Z =-SCZ
GO TO 20
10 Z =-SCZ+SCZ/3.0
GO TO 20
15 Z =-SCZ+(2.0*SCZ/3.0)
20 DO 59 K=1,IZ
Z=Z+SCZ
IT = 0
X=-SCX
DO 58 I=1,IX
X=X+SCX
ITT=IT+JJ+KT-1
IF(ITT-(ITT/2)*2) 57,30,57
30 RX(M)=X
RY(M)=Y+YLAX(J)
RZ(M)=Z
M = M+1
57 IT=IT+1
58 CONTINUE
KT=KT+1
59 CONTINUE
JT = JT + 1
IF(IDEEP-JT) 60,110,60
60 CONTINUE
LL=M-1
RETURN
110 LD=M-1
GO TO 60
END

```

```

SUBROUTINE D100
COMMON/COM1/RX(1000),RY(1000),RZ(1000),LCUT(1000),
1LL,LD,ITYPE,NVAC
COMMON/COM4/IX,IY,IZ,SCX,SCY,SCZ,IDEEP,D1X,D1Y,D1Z
RETURN
END

```

```

SUBROUTINE D110
COMMON/COM1/RX(1000),RY(1000),RZ(1000),LCUT(1000),
1LL,LD,ITYPE,NVAC
COMMON/COM4/IX,IY,IZ,SCX,SCY,SCZ,IDEEP,D1X,D1Y,D1Z
RETURN
END

```

```

SUBROUTINE D111
COMMON/COM1/RX(1000),RY(1000),RZ(1000),LCUT(1000),
1LL,LD,ITYPE,NVAC
COMMON/COM4/IX,IY,IZ,SCX,SCY,SCZ,IDEEP,D1X,D1Y,D1Z
RETURN
END

```

SUBROUTINE PLACE

C THIS SUBROUTINE LOCATES A VACANCY, INTERSTITIAL, OR REPLACEMENT IMPURITY IN THE LATTICE.

C COMMON/COM1/RX(1000),RY(1000),RZ(1000),LCUT(1000),  
1LL,LD,ITYPE,NVAC



```

COMMON/CCM4/IX,IY,IZ,SCX,SCY,SCZ,IDEEP,D1X,D1Y,D1Z
GO TO (10,20,30), ITYPE
10 LCUT(NVAC) = 1
   LCUT(1) = 1
   RX(1)=0.0
   RY(1)=0.0
   RZ(1)=0.0
   GO TO 40
20 RX(1) = RX(NVAC) - D1X
   RY(1) = RY(NVAC) - D1Y
   RZ(1) = RZ(NVAC) + D1Z
   GO TO 40
30 LCUT(NVAC) = 1
   RX(1) = RX(NVAC)
   RY(1) = RY(NVAC)
   RZ(1) = RZ(NVAC)
40 RETURN
END

```

### SUBROUTINE STEP

C THIS SUBROUTINE DOES THE DYNAMICS FOR ONE TIMESTEP.  
 THE FIRST HALF DOES THE DYNAMICS FOR ATOM #1; THE SECOND  
 HALF FOR ALL OTHERS.

```

C
COMMON/CCM1/RX(1000),RY(1000),RZ(1000),LCUT(1000),
1LL,LD,ITYPE,NVAC
COMMON/CCM5/ROE,ROE2,ROEM,EXA,EXB,PEXA,PEXB,FXA,PFXA,
1IQ,TSAVE,BSAVE
COMMON/CCM6/FX(1000),FY(1000),FZ(1000),PAC,PFPTC,FM
COMMON/CCM8/ROEA,ROEB,ROEC,ROEC2,CP0,CP1,CP2,CP3,
1CF0,CF1,CF2,CGD1,CGD2,CGB1,CGB2,CGF1,CGF2
IF(IQ.EQ.1) GO TO 200
I=1
IF(LCUT(I)) 200,105,200
105 IP=I+1
   DO 195 J=IP,LL
   IF(LCUT(J)) 195,110,195
110 DRX=RX(J)-RX(I)
   IF(DRX) 113,117,117
113 IF(DRX+ROE) 195,195,120
117 IF(DRX-ROE) 120,195,195
120 DRY=RY(J)-RY(I)
   IF(DRY) 123,127,127
123 IF(DRY+ROE) 195,195,130
127 IF(DRY-ROE) 130,195,195
130 DRZ=RZ(J)-RZ(I)
   IF(DRZ) 133,137,137
133 IF(DRZ+ROE) 195,195,140
137 IF(DRZ-ROE) 140,195,195
140 DIST=DRX*DRX+DRY*DRY+DRZ*DRZ
   IF(DIST-ROE2) 150,195,195
150 DIST=SQRT(DIST)
160 IF(DIST-ROEM) 162,162,165
162 FORCE=EXP(PFXA+PEXB*DIST)
   GO TO 180
165 DFF=ROE-DIST
   IF(DFF-1.0E-10) 195,195,167
167 FORCE=(EXP(PAC+PEXB*DIST)-PFPTC)/DFF
180 IF(FM-FORCE) 190,190,195
190 FOD=FORCE/DIST
   FA=FOD*DRX
   FX(J)=FX(J)+FA
   FX(I)=FX(I)-FA
   FA=FOD*DRY
   FY(J)=FY(J)+FA
   FY(I)=FY(I)-FA
   FA=FOD*DRZ
   FZ(J)=FZ(J)+FA
   FZ(I)=FZ(I)-FA
195 CONTINUE

```



```

C
200 DO 300 I=IQ,LD
    IF(LCUT(I)) 300,205,300
205 IP=I+1
    DO 295 J=IP,LL
    IF(LCUT(J)) 295,210,295
210 DRX=RX(J)-RX(I)
    IF(DRX) 213,217,217
213 IF(DRX+ROEC) 295,295,220
217 IF(DRX-ROEC) 220,295,295
220 DRY=RY(J)-RY(I)
    IF(DRY) 223,227,227
223 IF(DRY+ROEC) 295,295,230
227 IF(DRY-ROEC) 230,295,295
230 DRZ=RZ(J)-RZ(I)
    IF(DRZ) 233,237,237
233 IF(DRZ+ROEC) 295,295,240
237 IF(DRZ-ROEC) 240,295,295
240 DIST=DRX*DRX+DRY*DRY+DRZ*DRZ
    IF(DIST-ROEC2) 250,295,295
250 DIST=SQRT(DIST)
    IF(DIST-ROEA) 260,255,255
255 IF(DIST-ROEB) 265,270,270
260 FORCE=EXP(FXA+EXB*DIST)
    GO TO 280
265 FORCE=DIST*(DIST*CF2+CF1)+CF0
    GO TO 280
270 FORCE=EXP(CGF1+CGB1*DIST)-EXP(CGF2+CGB2*DIST)
280 IF(ABS(FORCE).LE.FM) GO TO 295
    FOD = FORCE/DIST
    FA=FOD*DRX
    FX(J)=FX(J)+FA
    FX(I)=FX(I)-FA
    FA=FOD*DRY
    FY(J)=FY(J)+FA
    FY(I)=FY(I)-FA
    FA=FOD*DRZ
    FZ(J)=FZ(J)+FA
    FZ(I)=FZ(I)-FA
295 CONTINUE
300 CONTINUE
    RETURN
    END

```

#### SUBROUTINE ENERGY

C THIS SUBROUTINE CALCULATES THE MUTUAL POTENTIAL ENERGIES. THE FIRST HALF DOES THE DYNAMICS FOR ATOM #1; THE SECOND HALF FOR ALL OTHERS.

```

C
COMMON/COM1/RX(1000),RY(1000),RZ(1000),LCUT(1000),
1LL,LD,ITYPE,NVAC
COMMON/COM5/ROE,ROE2,ROEM,EXA,EXB,PEXA,PEXB,FXA,PFXA,
1IQ,TSAVE,BSAVE
COMMON/COM7/PPTC,TPOT,PPE(1000),TLPE,ROEL,ROEL2,NEW
COMMON/COM8/ROEA,ROEB,ROEC,ROEC2,CPO,CP1,CP2,CP3,
1CF0,CF1,CF2,CGD1,CGD2,CGB1,CGB2,CGF1,CGF2
IF(IQ.EQ.1) GO TO 200
I=1
IF(LCUT(I)) 600,505,600
505 IP=I+1
    DO 595 J=IP,LL
    IF(LCUT(J)) 595,510,595
510 DRX=RX(J)-RX(I)
    IF(DRX) 513,517,517
513 IF(DRX+ROE) 595,595,520
517 IF(DRX-ROE) 520,595,595
520 DRY=RY(J)-RY(I)
    IF(DRY) 523,527,527
523 IF(DRY+ROE) 595,595,530
527 IF(DRY-ROE) 530,595,595

```



```

530 DRZ=RZ(J)-RZ(I)
      IF(DRZ) 533,537,537
533 IF(DRZ+ROE) 595,595,540
537 IF(DRZ-ROE) 540,595,595
540 DIST=DRX*DRX+DRY*DRY+DRZ*DRZ
      IF(DIST-ROE2) 550,595,595
550 DIST=SQRT(DIST)
560 POT=EXP(PEXA+PEXB*DIST)-PPTC
580 TPOT=TPOT+POT
      PPE(I)=PPE(I)+BSAVE*POT
      PPE(J)=PPE(J)+TSAVE*POT
595 CONTINUE
600 CONTINUE
C
200 DO 300 I=IQ,LL
      IF(LCUT(I)) 300,205,300
205 IP=I+1
      DO 295 J=IP,LL
      IF(LCUT(J)) 295,210,295
210 DRX=RX(J)-RX(I)
      IF(DRX) 213,217,217
213 IF(DRX+ROEC) 295,295,220
217 IF(DRX-ROEC) 220,295,295
220 DRY=RY(J)-RY(I)
      IF(DRY) 223,227,227
223 IF(DRY+ROEC) 295,295,230
227 IF(DRY-ROEC) 230,295,295
230 DRZ=RZ(J)-RZ(I)
      IF(DRZ) 233,237,237
233 IF(DRZ+ROEC) 295,295,240
237 IF(DRZ-ROEC) 240,295,295
240 DIST=DRX*DRX+DRY*DRY+DRZ*DRZ
      IF(DIST-ROEC2) 250,295,295
250 DIST=SQRT(DIST)
      IF(DIST-ROEA) 260,255,255
255 IF(DIST-ROEB) 265,270,270
260 POT=EXP(EXA+EXB*DIST)
      GO TO 280
265 POT=DIST*(DIST*(DIST*CP3+CP2)+CP1)+CPO
      GO TO 280
270 POT=EXP(CGD1+CGB1*DIST)-EXP(CGD2+CGB2*DIST)
280 TPOT=TPOT+POT
      SAVE=0.5*POT
      PPE(I)=PPE(I)+SAVE
      PPE(J)=PPE(J)+SAVE
295 CONTINUE
300 CONTINUE
      RETURN
      END

```

#### SUBROUTINE LOCAL

C THIS SUBROUTINE CALCULATES THE TOTAL POTENTIAL ENERGY IN A  
C SMALL VOLUME AROUND A VACANCY OR INTERSTITIAL.

```

COMMON/COM1/RX(1000),RY(1000),RZ(1000),LCUT(1000),
1 LL,LD,ITYPE,NVAC
COMMON/COM7/PPTC,TPOT,PPE(1000),TLPE,ROEL,ROEL2,NEW
DIMENSION LCCAT(500)
K=1
TLPE=0.0
IF(NEW.EQ.1)GO TO 305
8 GO TO (10,20,20),ITYPE
10 I=NVAC
GO TO 200
20 I=1
200 DO 300 J=1,LD
      IF(I.EQ.J) GO TO 250
210 DRX=RX(J)-RX(I)
      IF(DRX) 213,217,217
213 IF(DRX+ROEL) 295,295,220

```





```

217 IF(DRX-ROEL) 220,295,295
220 DRY=RY(J)-RY(I)
    IF(DRY) 223,227,227
223 IF(DRY+ROEL) 295,295,230
227 IF(DRY-ROEL) 230,295,295
230 DRZ=RZ(J)-RZ(I)
    IF(DRZ) 233,237,237
233 IF(DRZ+ROEL) 295,295,240
237 IF(DRZ-ROEL) 240,295,295
240 DIST=DRX*DRX+DRY*DRY+DRZ*DRZ
    ROEL2=ROEL*ROEL
    IF(DIST-ROEL2) 250,295,295
250 LOCAT(K)=J
    K=K+1
295 CONTINUE
300 CONTINUE
    KF=K-1
305 DO 310 K=1,KF
    TLPE=TLPE+PPE(LOCAT(K))
310 CONTINUE
    NEW=1
    RETURN
    END

```

SUBROUTINE PRINT

C THIS SUBROUTINE PRINTS THE HEADING OF ALL PERTINENT INFORMATION AT THE TOP OF EACH TIMESTEP PRINTOUT.  
C

```

COMMON/COM1/RX(1000),RY(1000),RZ(1000),LCUT(1000),
1LL,LD,I TYPE,NVAC
COMMON/COM2/IH1(20),IH2(8),IHS(10),IHB(6),IHT(6),
1TARGET(4),TMAS,BULLET(4),BMAS,PLANE,TEMP,THERM
COMMON/COM3/RXI(1000),RYI(1000),RZI(1000),CVR,EVR,
1NT,TIME,DT,DTI,ILAY
COMMON/COM4/IX,IY,IZ,SCX,SCY,SCZ,IDEEP,D1X,D1Y,D1Z
COMMON/COM5/ROE,ROE2,ROEM,EXA,EXB,PEXA,PEXB,FXA,PFXA,
1IQ,TSAVE,BSAVE
COMMON/COM8/ROEA,ROEB,ROEC,ROEC2,CP0,CP1,CP2,CP3,
1CFC,CF1,CF2,CGD1,CGD2,CGB1,CGB2,CGF1,CGF2
9710 FORMAT(4X,10A4,/,28X,2CA4,/)
9720 FORMAT(9H TARGET -,4A4,10HPRIMARY -,4A4,1X,14HLATTICE
1 UNIT =,F7.4,4H ANG)
9730 FORMAT(4X,6HMASS =,F7.2,13X,6HMASS =,F7.2,9X,14HLATTIC
1E TEMP =F5.2,7H DEG K,18H THERMAL CUTOFF =,F5.2,3H E
1V/)
9740 FORMAT(2H (,A4,8H) PLANE,,18H PRIMARY ENERGY =,
1 F5.2,21HKEV, CRYSTAL SIZE ( ,12,3H X ,12,3H X ,12,3H
1 ),, 4X, 16HVACANCY IN SITE , 14/)
9741 FORMAT(2H (,A4,8H) PLANE,,18H PRIMARY ENERGY =,
1 F5.2,21HKEV, CRYSTAL SIZE ( ,12,3H X ,12,3H X ,12,3H
1 ),, 4X, 15HINTERSTITIAL (-,F5.2,2H,-,F5.2,2H,+,F5.2,
112H) FROM SITE ,14/)
9742 FORMAT(2H (,A4,8H) PLANE,,18H PRIMARY ENERGY =,
1 F5.2,21HKEV, CRYSTAL SIZE ( ,12,3H X ,12,3H X ,12,3H
1 ),, 4X, 20HREPLACEMENT IN SITE , 14/)
9750 FORMAT(30H PRIMARY START POINT (LU) X =,F5.2,5H, Y =,
1F5.2,5H, Z =,F5.2,5X,I3,' LAYERS ARE FREE TO MOVE',
110X,4HIQ =,I2/)
9760 FORMAT(12H POTENTIAL ,6A4,3X,5HPEXA=,F9.5,2X,5HPEXB=,
1F9.5,2X,5HPFXA=,F9.5)
9765 FORMAT(12X,6A4,3X,5HEXA =,F9.5,2X,5HEXB =,F9.5,2X,5HFX
1A =,F9.5/)
9770 FORMAT(' WHEN',F8.4,' < R <',F8.4,' THE MATCHING POTEN
1TIAL PARAMETERS ARE',//,' CPO =',F10.3,' , CP1 =',
1F10.3,' , CP2 =',F10.3,' , CP3 =',F10.3,' , CFC =',
1E10.3,' , CF1 =',E10.3,' , CF2 =',E10.3,//)
9780 FORMAT(' CUT-OFF AT',F5.2,' , WHEN R >',F6.3,' LU, MOR
1SE POTENTIAL PARAMETERS ARE', 8A4,//,10X,' CGD1 =',
1F8.4,' , CGD2 =',F8.4,' , CGB1 =',F8.4,' , CGB2 =',F8.4,
1' , CGF1 =',F8.4,' , CGF2 =',F8.4,//)

```



```

9790 FORMAT(10H TIMESTEP ,I4,22X,6HDTI = , F5.3, 5H LU, ,
122H ELAPSED TIME (SEC) =, E10.4,21H; LAST TIMESTEP WA
1S =, E10.4/)
WRITE ( 6,9710) IHS,IH1
WRITE ( 6,9720) TARGET,BULLET,CVR
WRITE ( 6,9730) TMAS,BMAS,TEMP,THERM
GO TO (401,402,403), ITYPE
401 WRITE ( 6,9740) PLANE,EVR,IX,IY,IZ,NVAC
GO TO 405
402 WRITE ( 6,9741) PLANE,EVR,IX,IY,IZ,D1X,D1Y,D1Z,NVAC
GO TO 405
403 WRITE ( 6,9742) PLANE,EVR,IX,IY,IZ,NVAC
405 WRITE ( 6,9750) RXI(1),RY1(1),RZI(1),ILAY,IQ
WRITE ( 6,9760) IHB,PEXA,PEXB,PFXA
WRITE ( 6,9765) IHT,EXA,EXB,FXA
WRITE ( 6,9770) ROEA,ROEB,CP0,CP1,CP2,CP3,CF0,CF1,CF2
WRITE ( 6,9780) ROEC,ROEB,IH2,CGD1,CGD2,CGB1,CGB2,
1CGF1,CGF2
WRITE ( 6,9790) NT,DTI,TIME,DT
RETURN
END

```



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KEY WORDS	LINK A		LINK B		LINK C	
	ROLE	WT	ROLE	WT	ROLE	WT
Computer Simulation						
Tungsten Desorption Energies						
Interstitials in Tungsten						
Substitutional Impurities in Tungsten						













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